

Development of 1550nm InAs on InP emitting QD Lasers

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TECHNION
Israel Institute
of Technology



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Interdisciplinary Nanostructure
Science and Technology



U N I K A S S E L
V E R S I T Ä T

Involved People

1.5 μm InP Based QD lasers

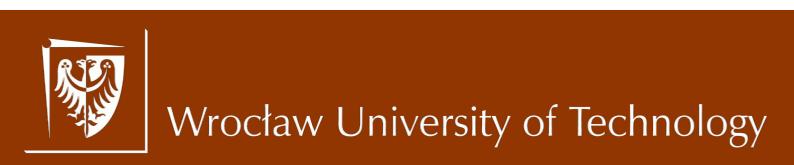
Vitalii Sichkovskyi, J.P. Reithmaier

- S. Banyoudeh, A. Abdollahinia (high-speed lasers)
- Annette Becker (narrow linewidth lasers)
- Florian Schnabel, Anna Rippie (processing)



Further Cooperations

- **Technion:** **Gadi Eisenstein**, Ori Eyal, Tali Septon, Sutapa Gosh,
(→ High-speed QD lasers, QD-SOAs, narrow-linewidth lasers)
- **Kassel Univ.:** **Bernd Witzigmann**, Marco Bjelica (CEP)
- **TU Wroclaw:** **Grzegorz Sek et al.**
- **Nvidia/Mellanox:** **Isabelle Cestier, Elad Mentovitch**



Low-Dimensional Gain Material and Impact on Device Properties

InP-based QD Lasers

High-Temperature Stable QD Lasers

Narrow-Linewidth QD-DFB-Lasers

Outlook (Extended wavelength range)

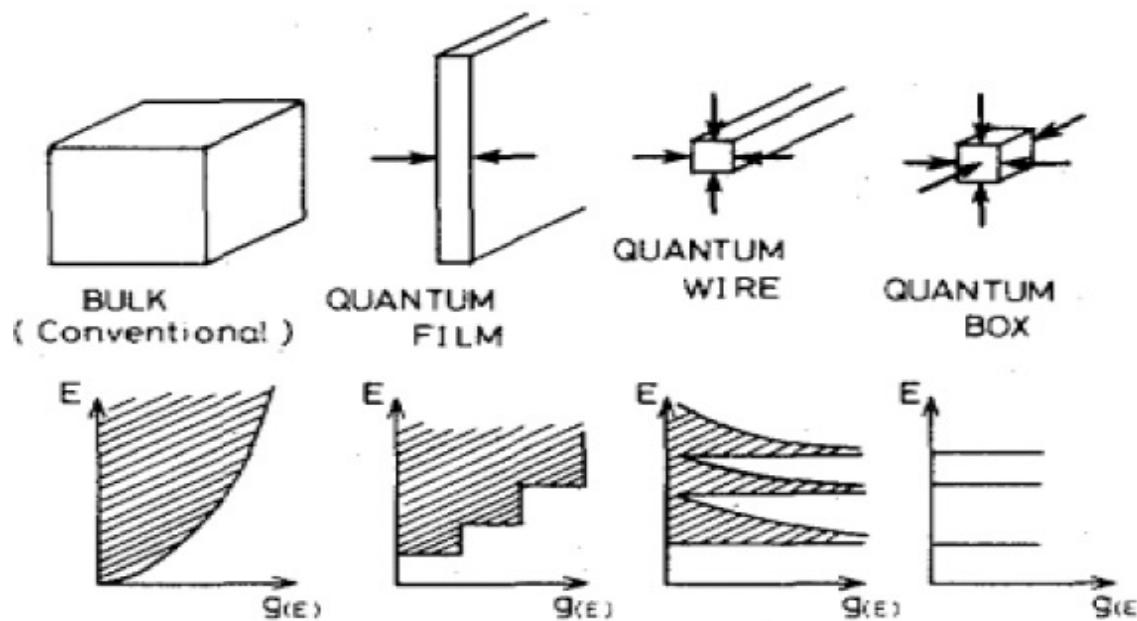
Summary



Low-Dimensional Gain Material and Impact on Device Properties



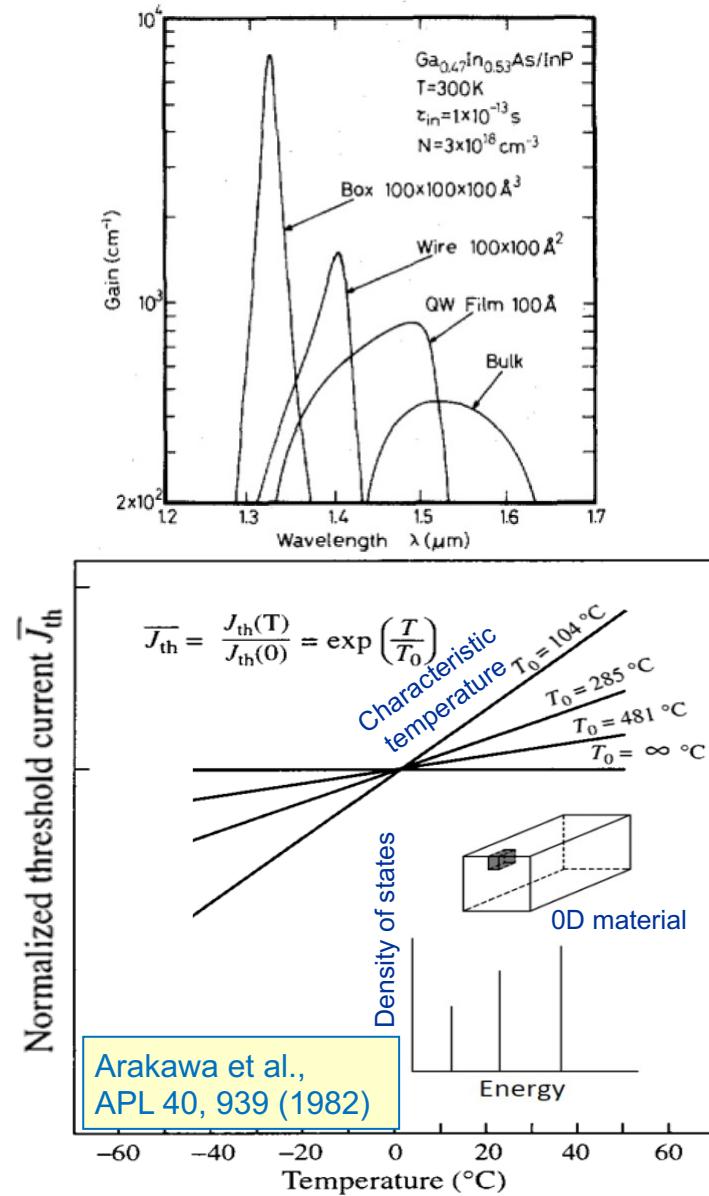
Material gain of low-dimensional material



Asada et al., IEEE JQE 22, 1915 (1986)

Major statement:

- 10 times higher gain than in QWs
 - in ideal case no temperature dependence
- Only applicable in case of
 - small size distribution (atom-like),
 - high QD density (high modal gain)
 - and large level splitting ($\gg kT$)



Arakawa et al.,
APL 40, 939 (1982)

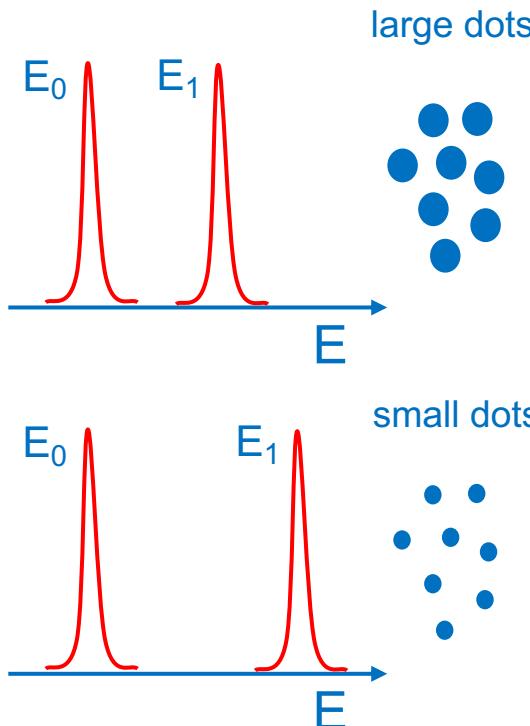


Engineering of Optical Gain by QD Material

Three main parameters

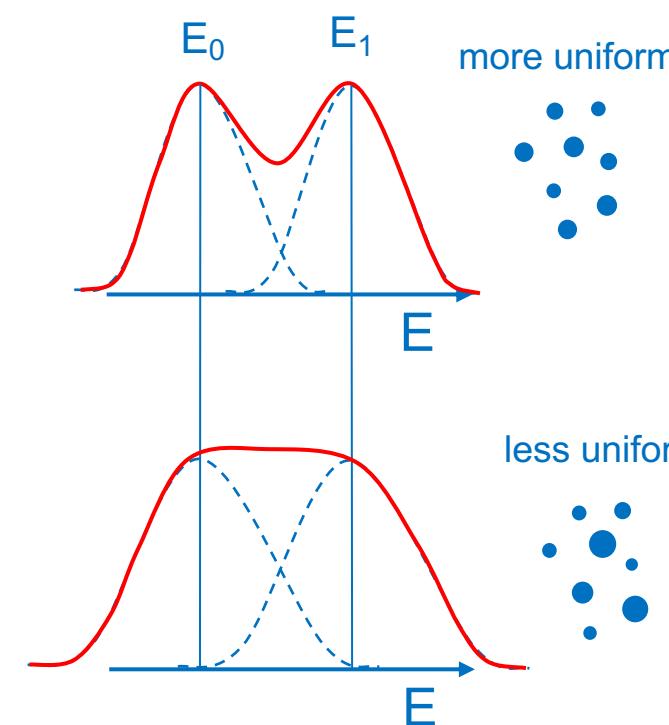
Dot size:

→ level splitting



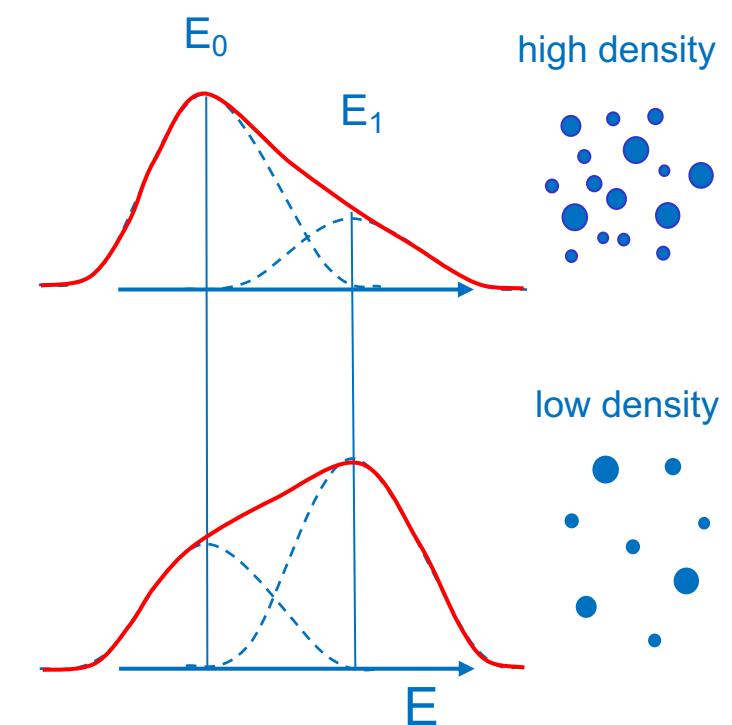
Size distribution:

→ gain flatness



Dot density:

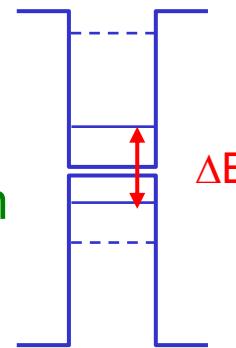
→ gain saturation



Advantages of atom-like gain material

Static Properties

- Very high temperature stability
- Zero threshold and low power consumption
- Very narrow linewidth (α , R'_{sp})



Laser Linewidth

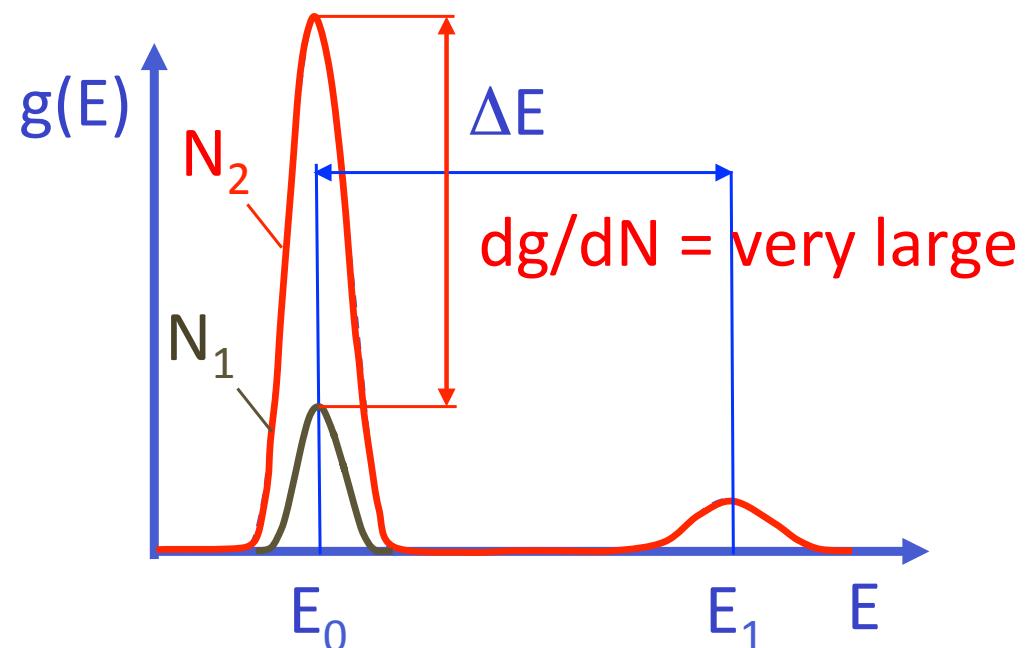
$$\Delta\nu = \frac{\Gamma R'_{sp}}{4\pi N_p} (1 + \alpha^2)$$
$$\alpha = -\frac{4\pi}{\lambda} \frac{dn/dN}{dg/dN}$$

Dynamic Properties

- Very high differential gain $a = dg/dN$
- Zero chirp ($\alpha = 0$)

Resonance Frequency

$$\omega_R \propto \sqrt{a \cdot \frac{N_p}{\tau_p}}$$

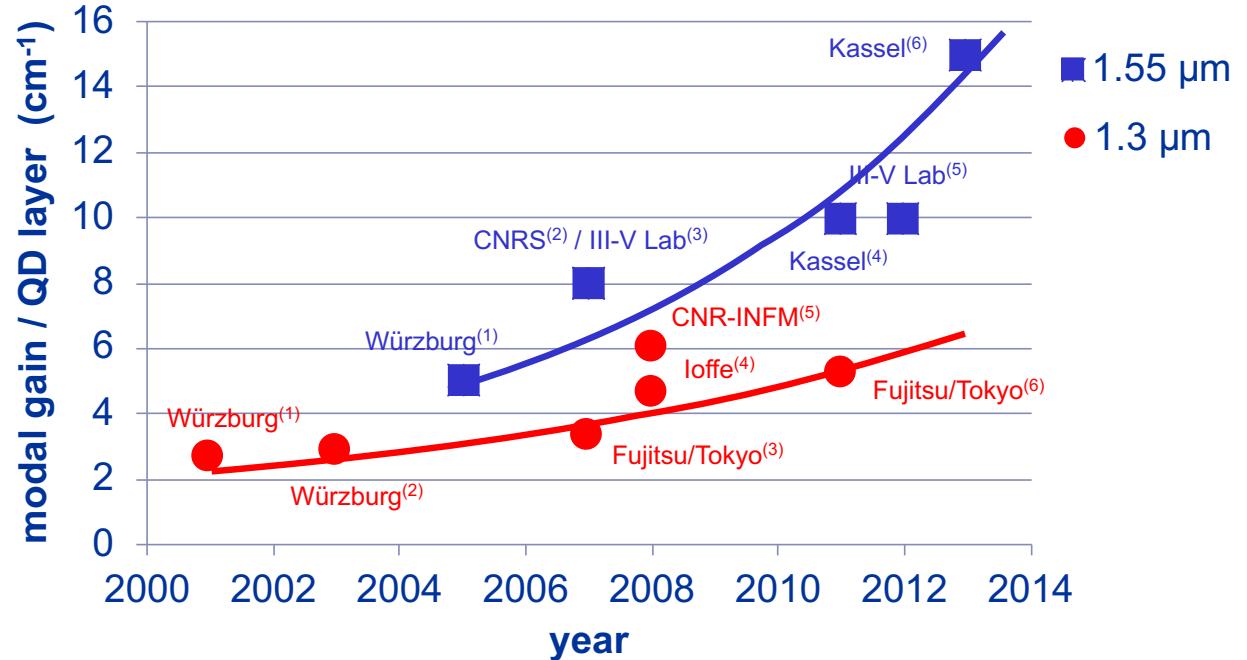


Why InP-based 1.3 μm QD Lasers?

Usually, 1.3 μm QD lasers based on GaAs

InP-based QD lasers

- Modal gain typically by a factor of 3 higher
- Allow short cavity devices (<< 1 mm)



Additional advantages of InP-based QD lasers

- Much less strained QDs (InP: 3.2 % / GaAs: 7.2%)
→ Improved reliability expected
- Larger wavelength variability (> 100 nm gain range possible)
- Tensile strained barriers possible for strain compensation

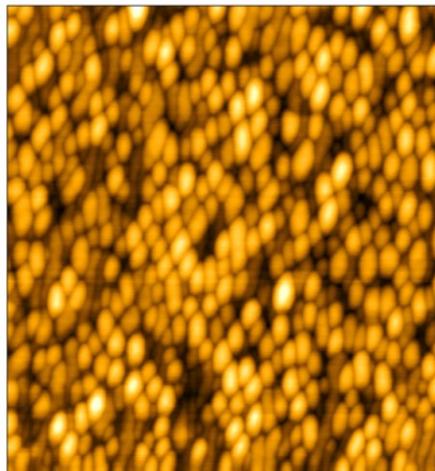


InP-based QD Lasers

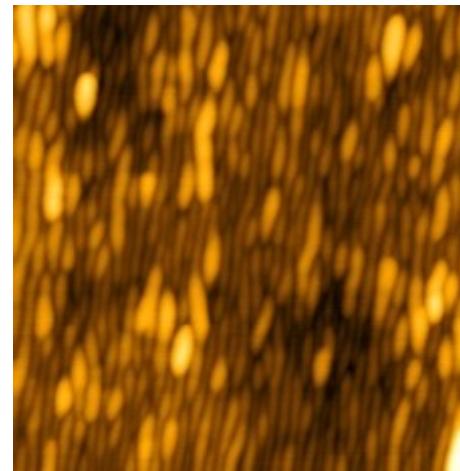


QD Formation on InP-based Compound Surfaces

As₂ growth mode



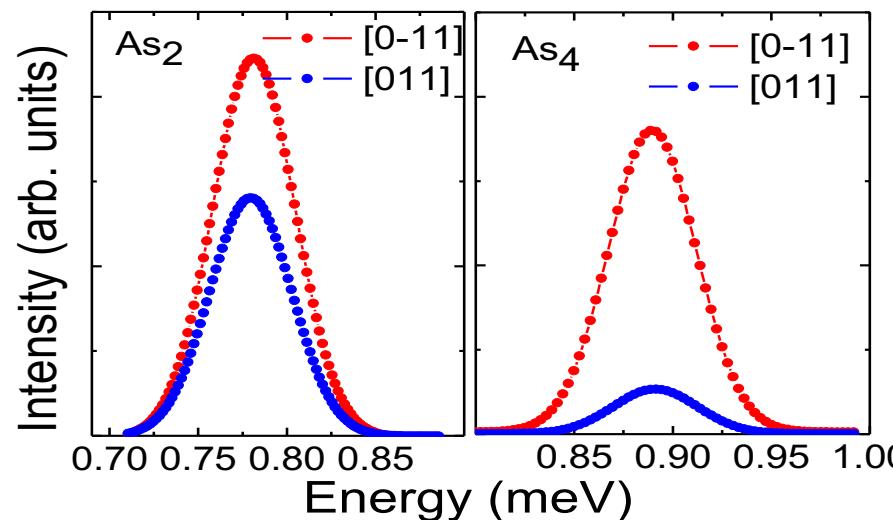
As₄ growth mode



C. Gilfert et. al., APL 96, 191903 (2010)

→ Quantum dots are formed only by supplying As₂ during InAs deposition

Polarization



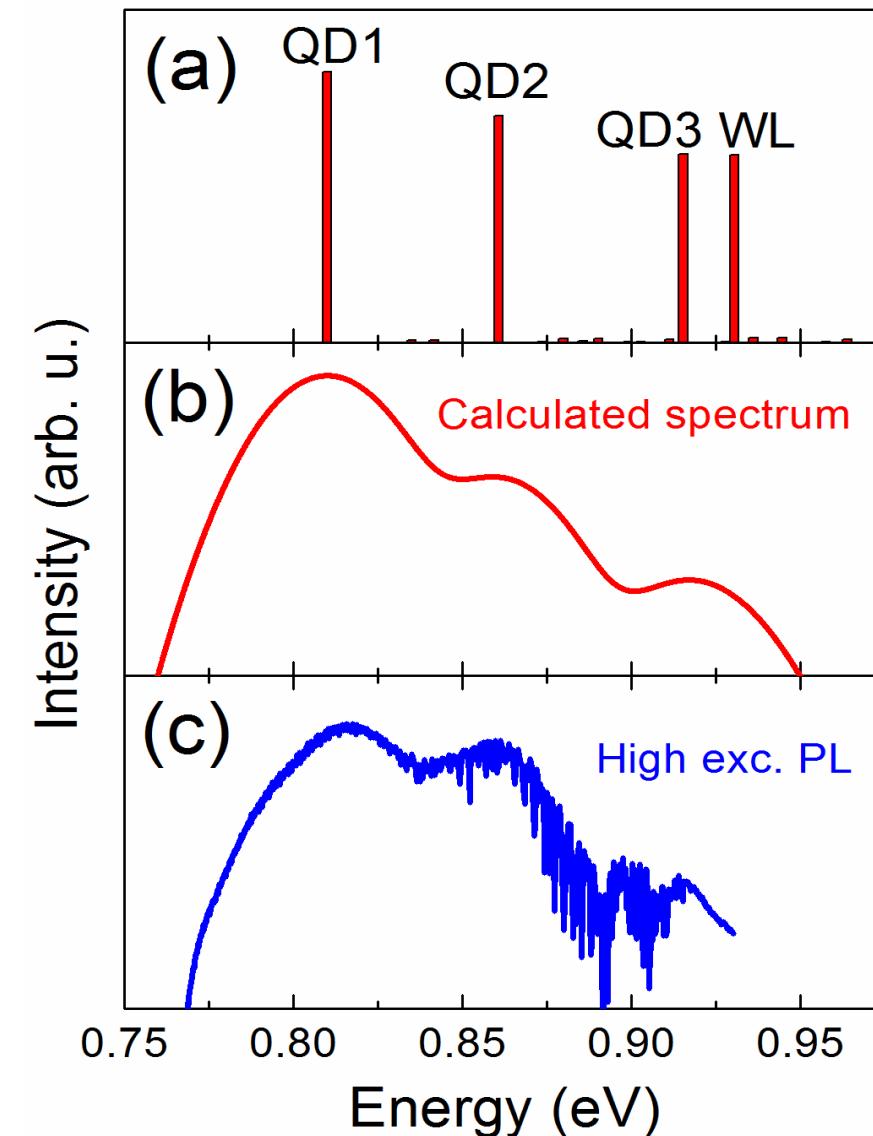
Quantum State Calculations and Verification

- Electron and hole state calculations using multi-band $k \bullet p$ theory
- Clear identification of QD-like behavior with confined excited states
- Verification by high-power excitation photoluminescence

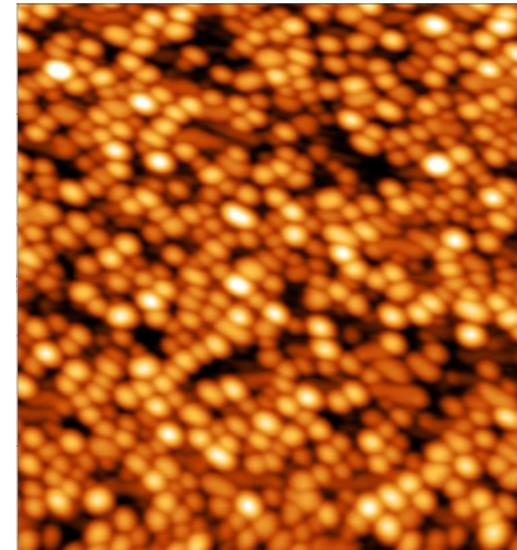
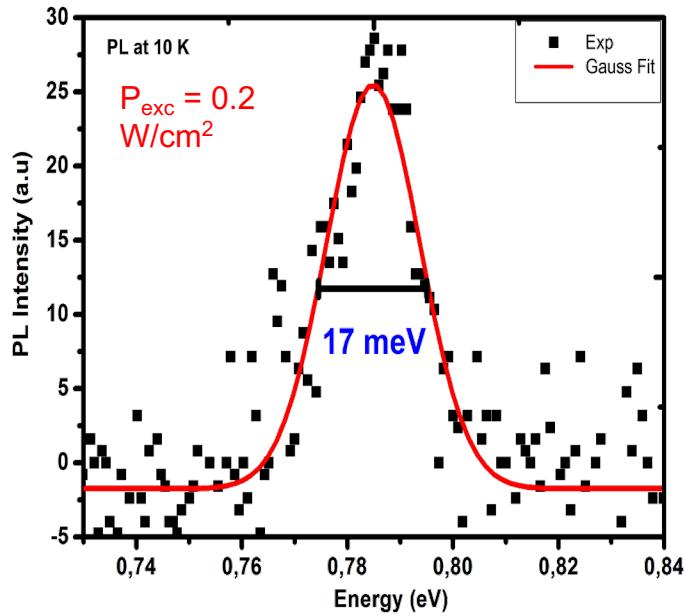
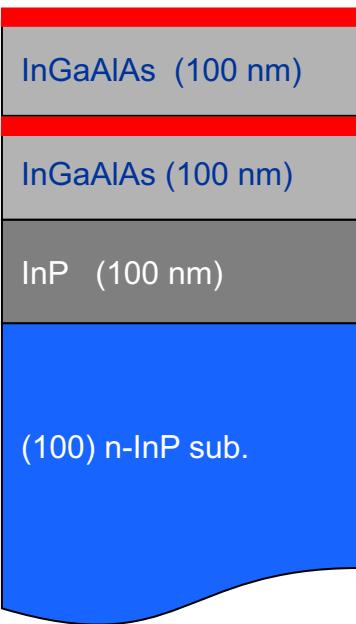


Wrocław University of Technology

A. Marynski et. al., JAP 114, 094306 (2013)



Quantum dot material

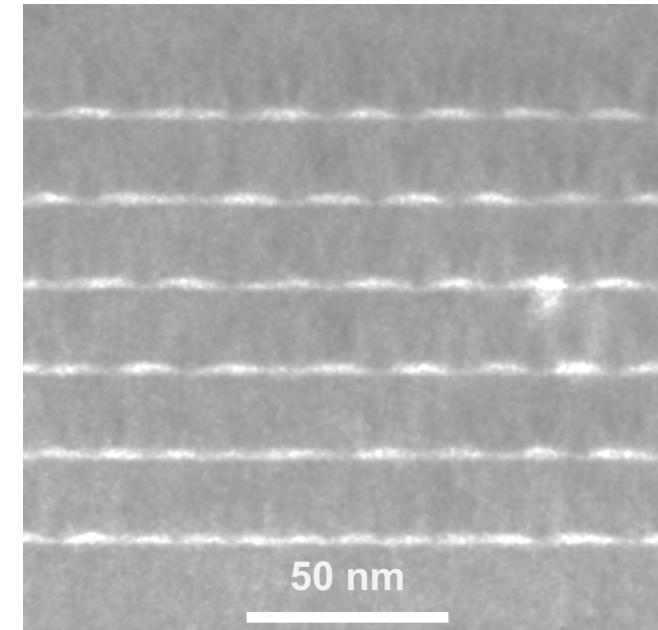
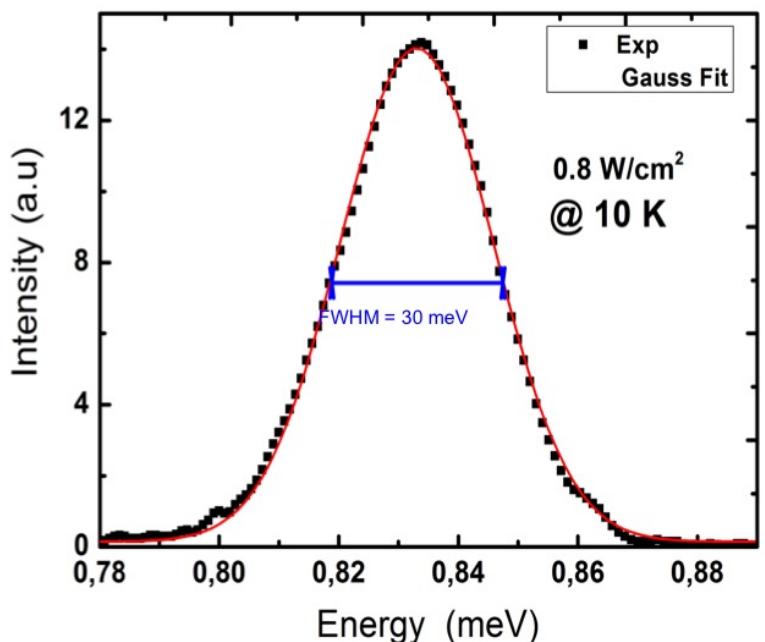
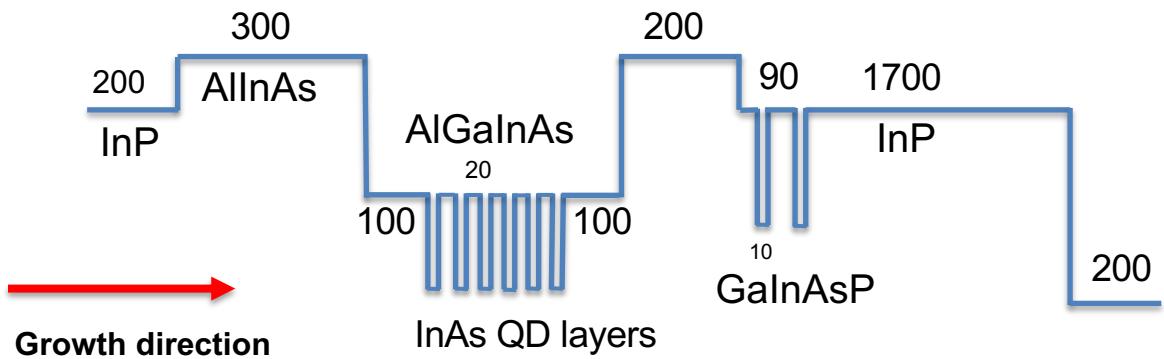


- nearly circular shaped QDs of high dot densities ($5-6 \times 10^{10} \text{ cm}^{-2}$)
- Single QD layer with very small size variations
- Record linewidth of 17 meV for single QD layer

S. Banyoudeh et al., JCG 425, 299 (2015)



Layer design of high-speed QD lasers



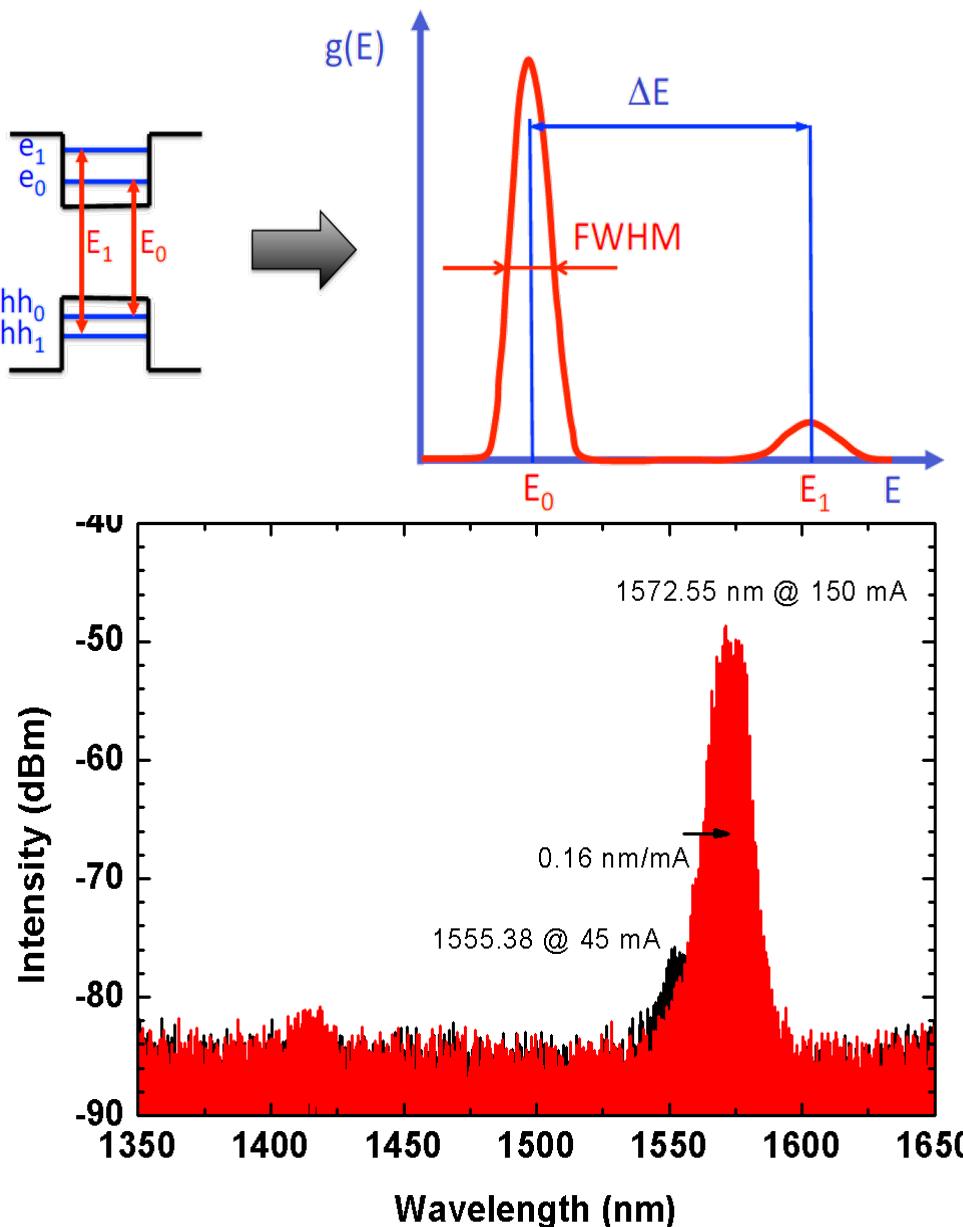
A. Rosenauer



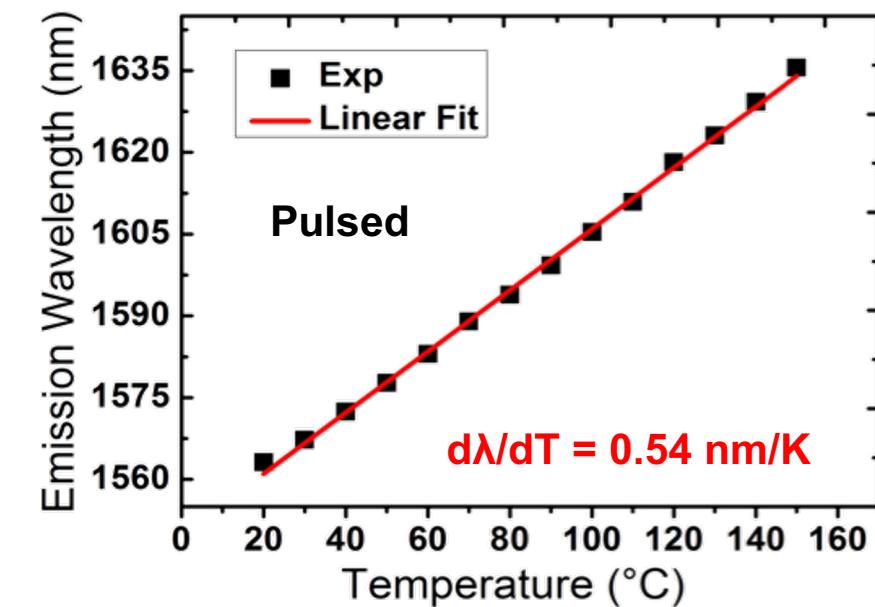
- Laser design with 6 QD layers and high optical confinement
- Narrow ensemble linewidth for 6 stacked QD layers with FWHM = 30 meV



Fundamental Properties of QD Lasers



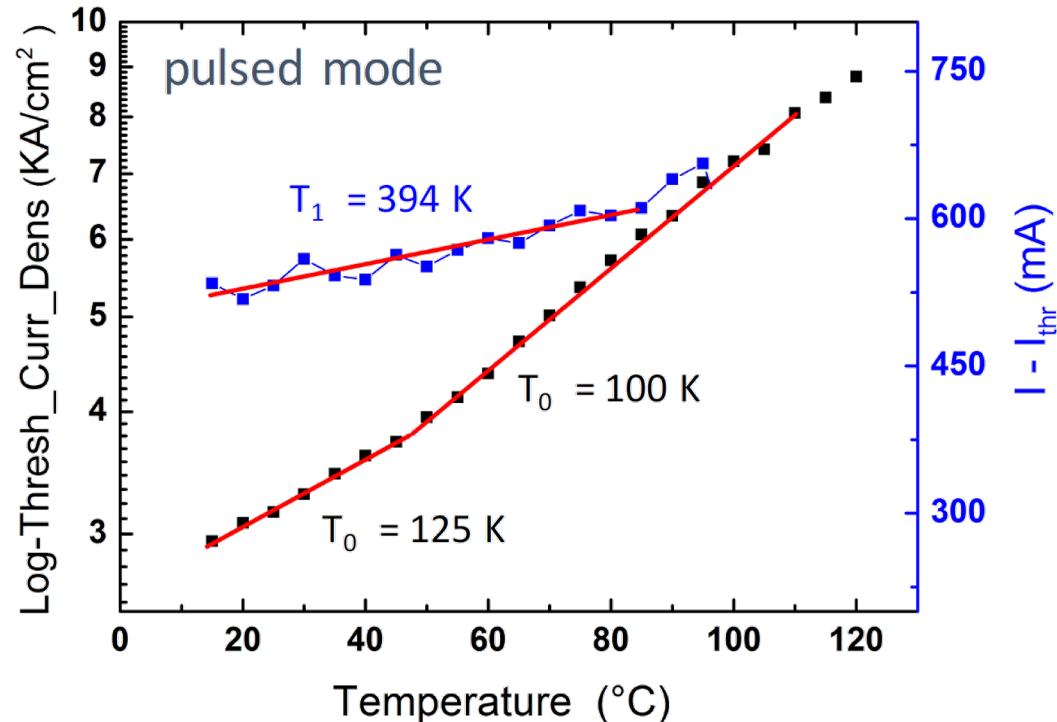
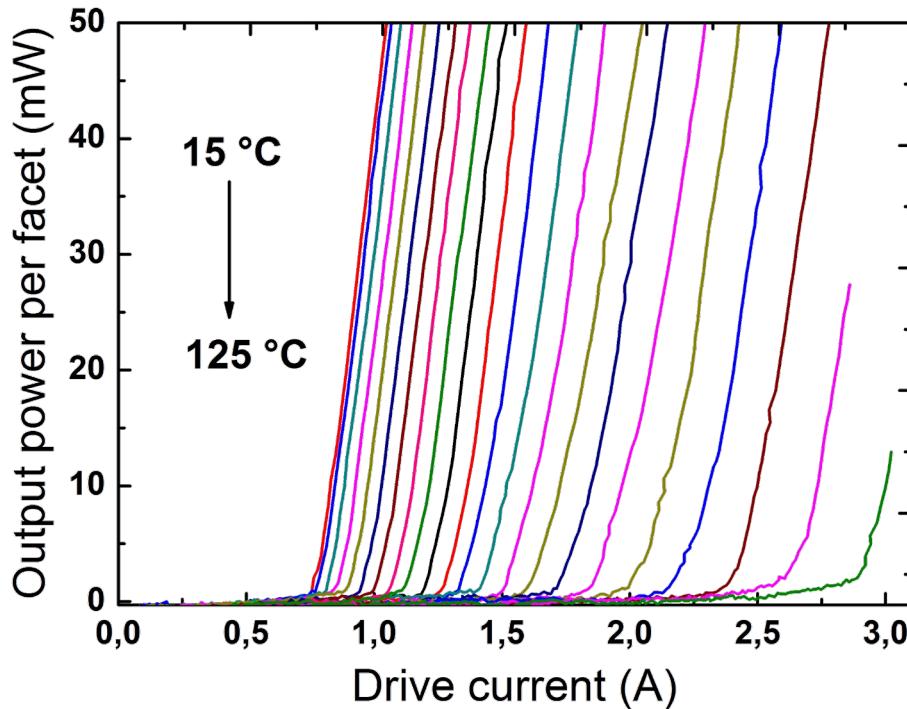
- Atomic-like gain function
- Symmetric ground state gain
- Stable ground state gain at any operation condition



High-Temperature Stable QD Lasers



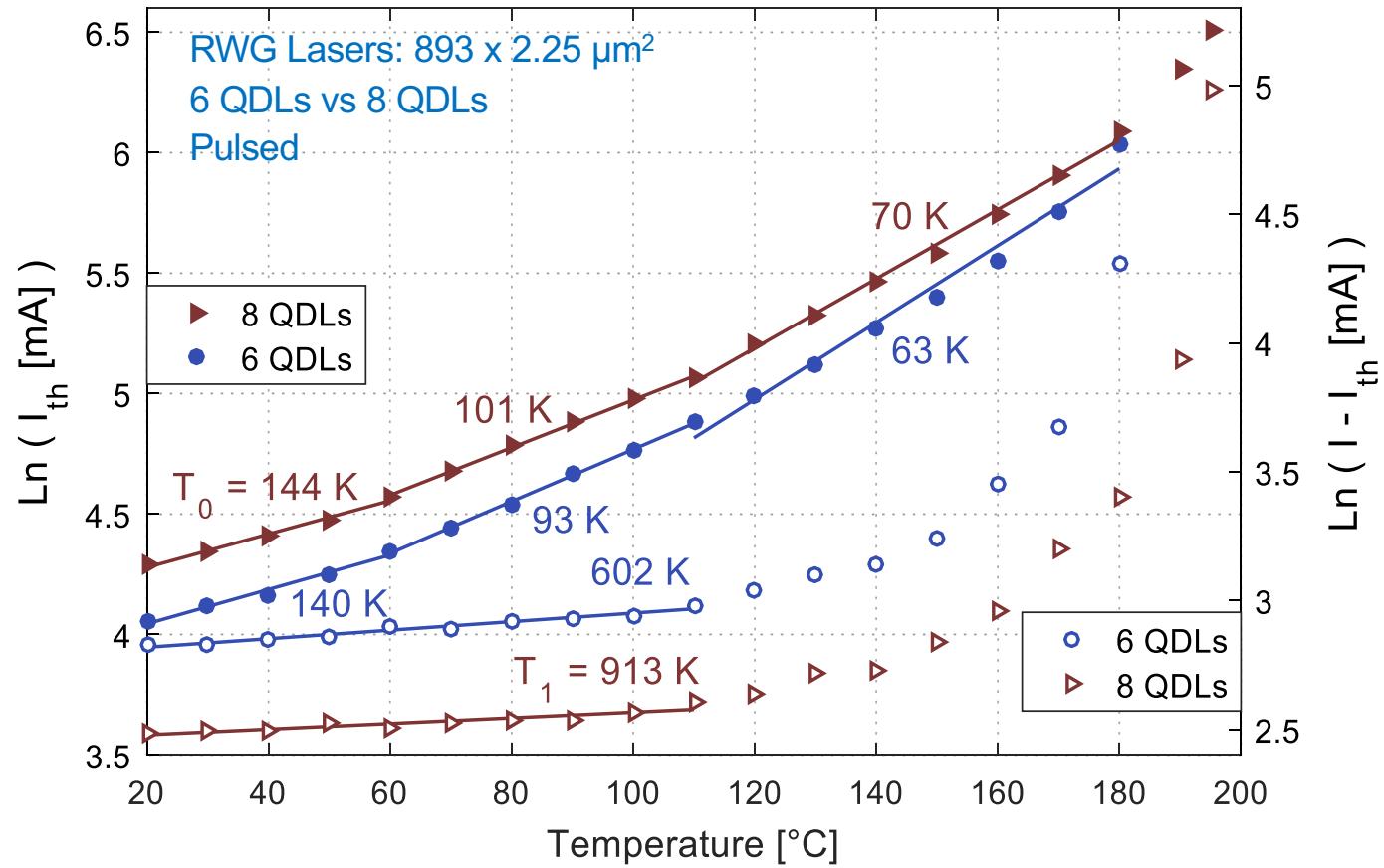
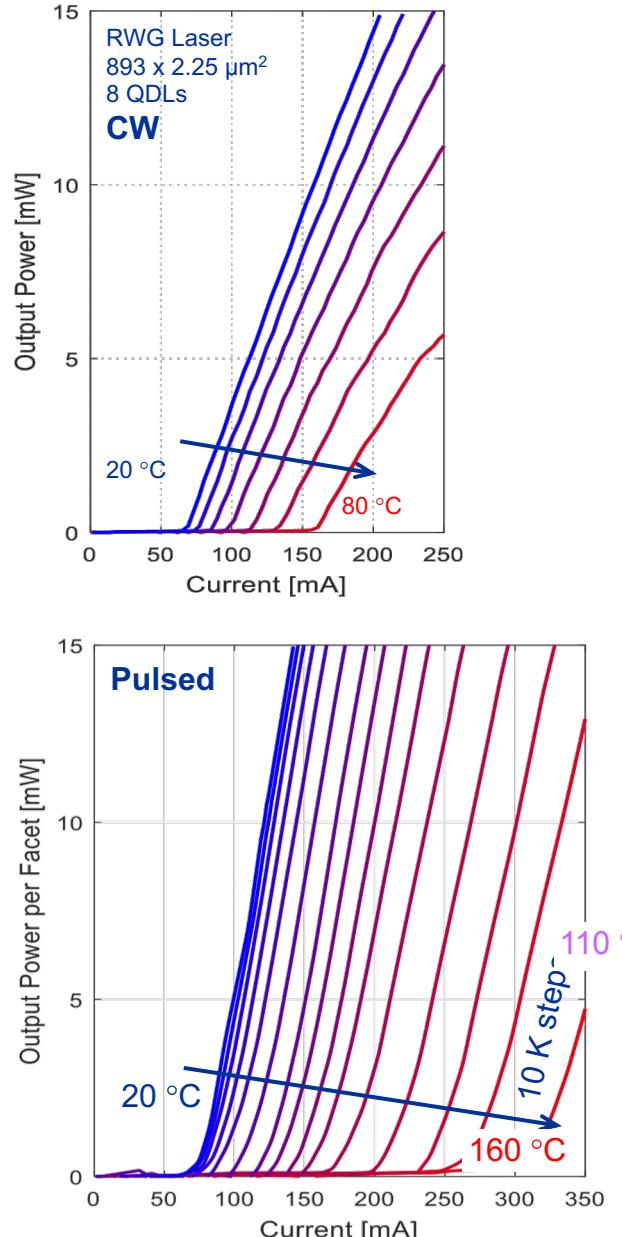
Characteristic temperatures in broad area lasers



- Broad area lasers with 100 μm stripe width and 292 μm cavity length
- Nearly constant slope efficiency from 15 – 125 °C
- High characteristic temperature T_0 of 125 K (45 °C), > 100 K (above)
- High output power stability with T_1 of 394 K (@80 mW, 15 to 95 °C)



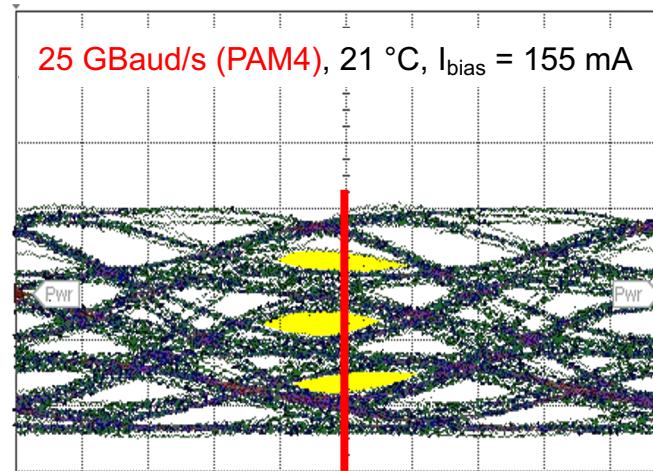
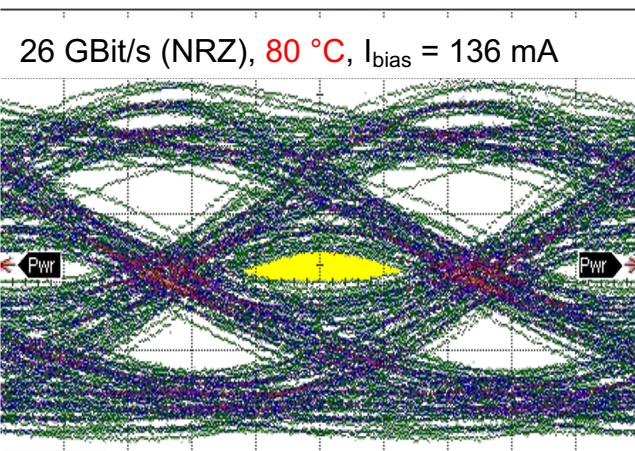
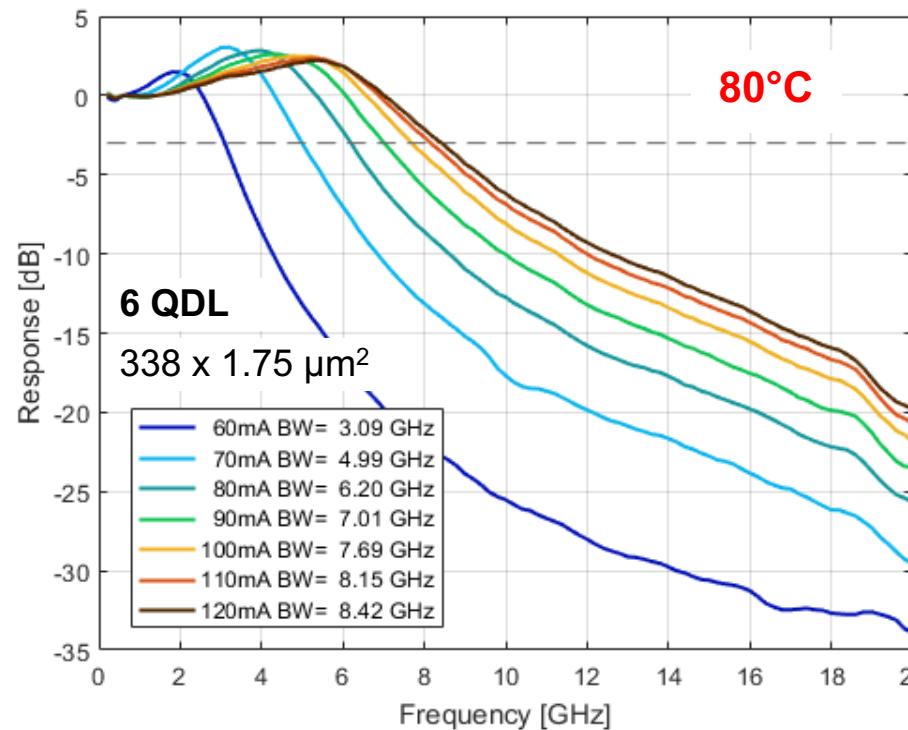
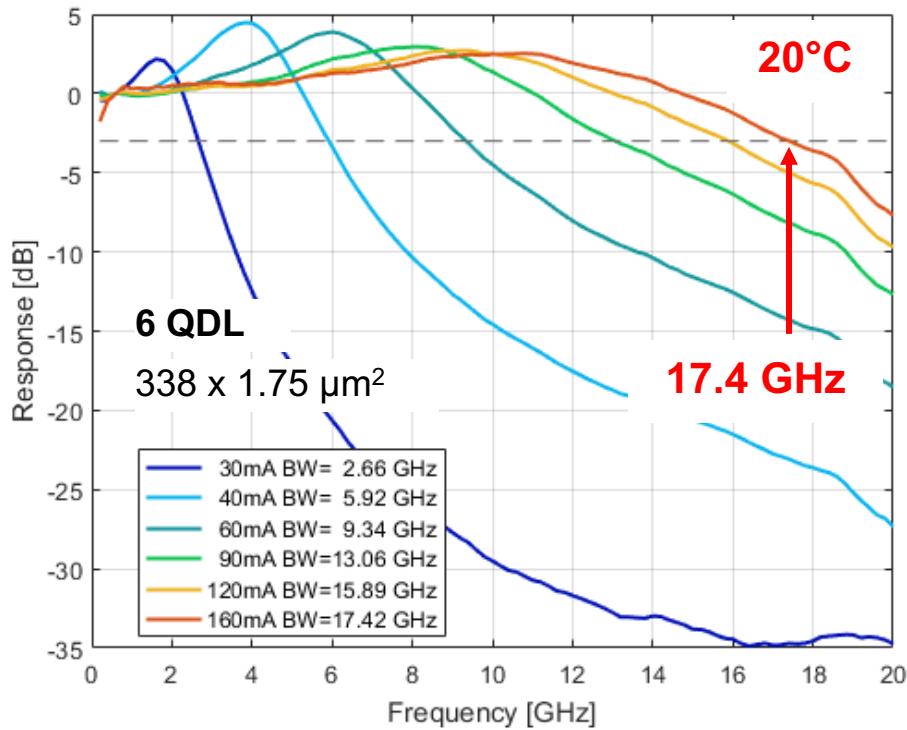
Impact of epitaxial design on temperature stability



- $T_0 > 140 \text{ K}$ ($20 - 60 \text{ }^\circ\text{C}$) and > 100 (up to $110 \text{ }^\circ\text{C}$)
- higher temperature stability with lasers of 8 QD layers



Small-Signal Modulation Response



A. Abdollahinia et al., Optics Express 26, 6056 (2018)

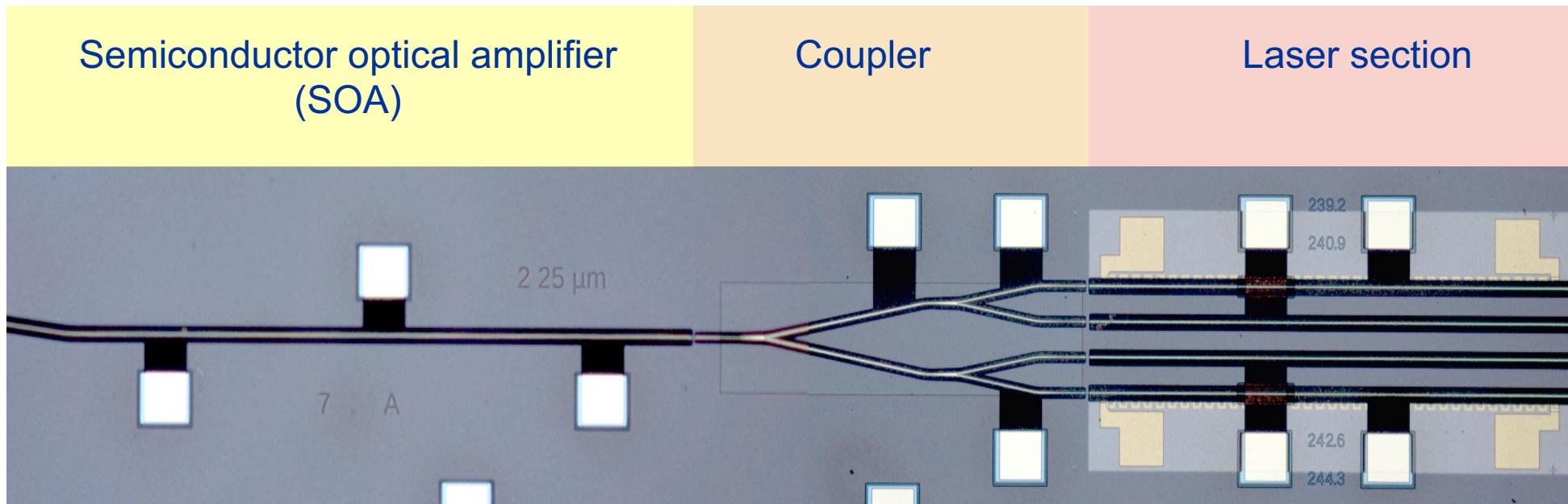
S. Bauer et al., IEEE Nanotechnology Magazine 23 (2021)



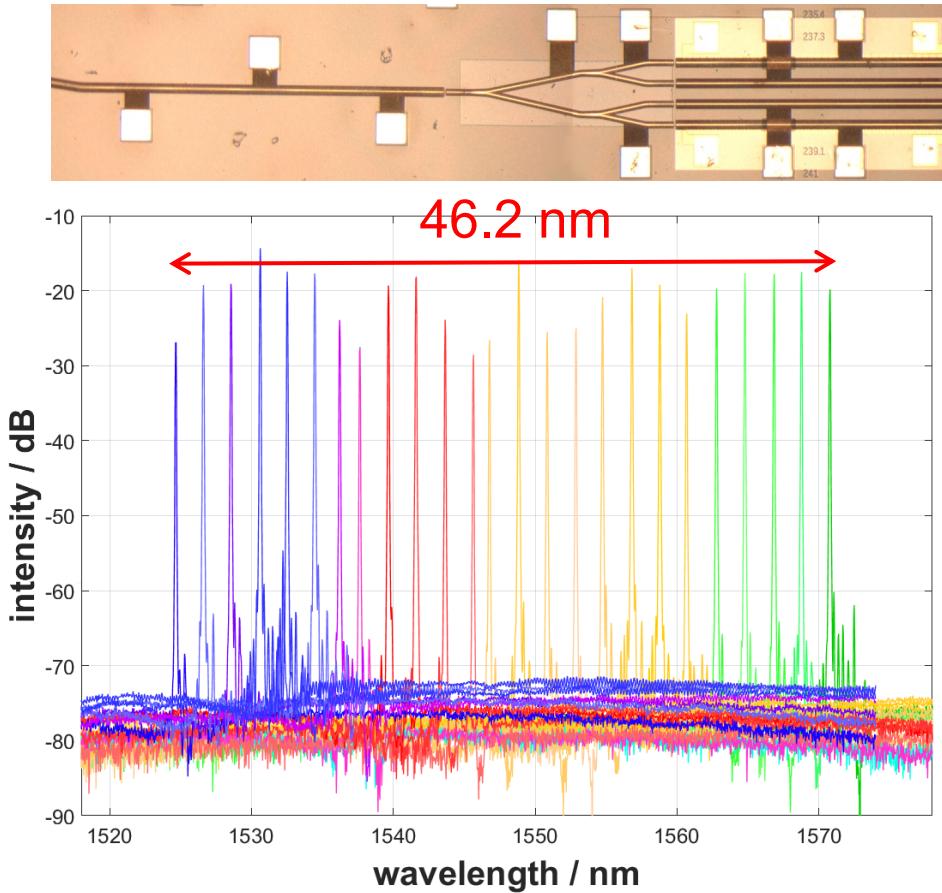
Narrow-Linewidth QD-DFB-Lasers



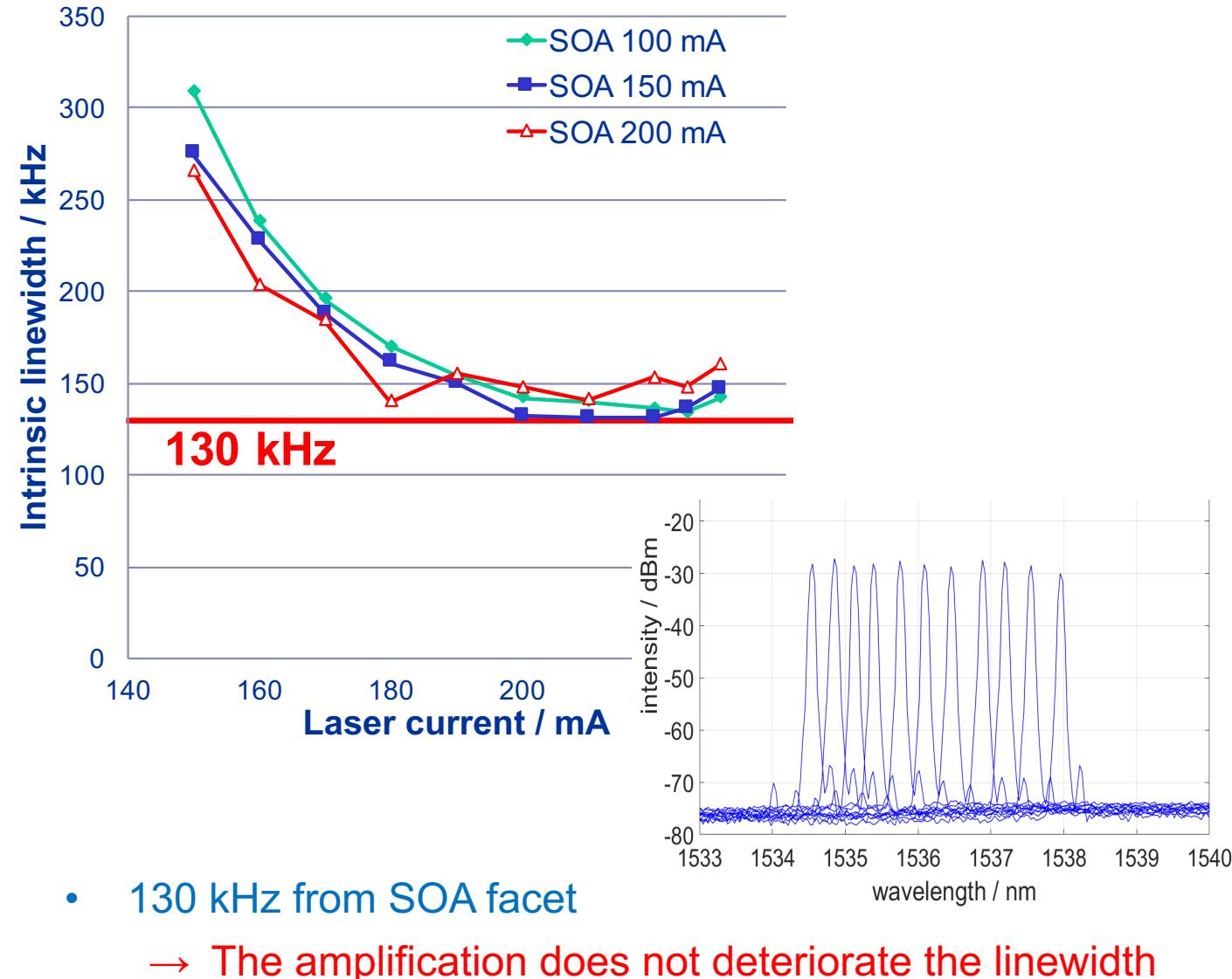
- Local oscillators for coherent communication need narrow linewidth and broadband tunability
 - Linewidth reduction by using QD material
 - Expanding tuning range to > 40 nm by using arrayed lasers
 - Adjusting output power by using broadband SOA



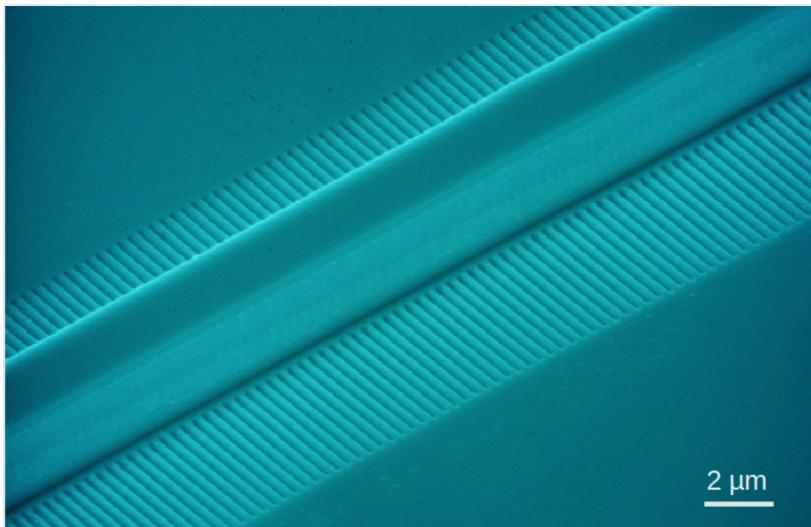
New generation of tunable narrow linewidth source



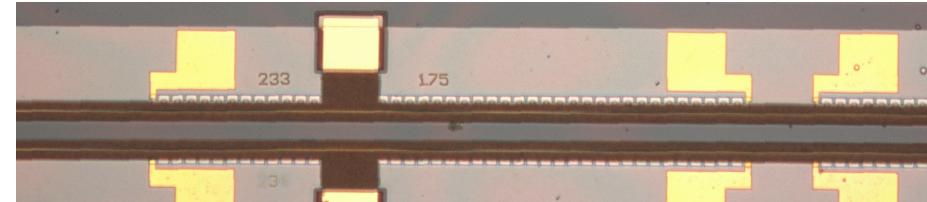
- Mounted chip, laser facet HR, SOA facet AR coated
- Wide tuning range (whole C+ band)



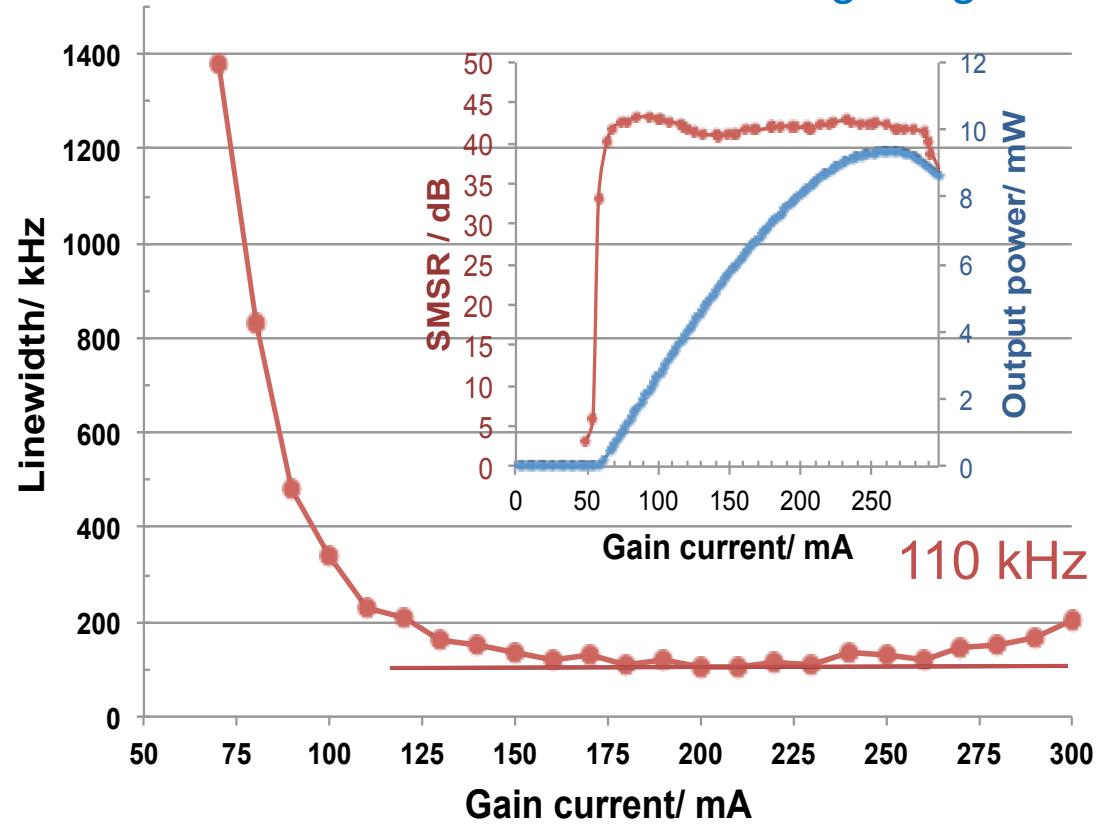
Emission linewidth of single QD DFB laser



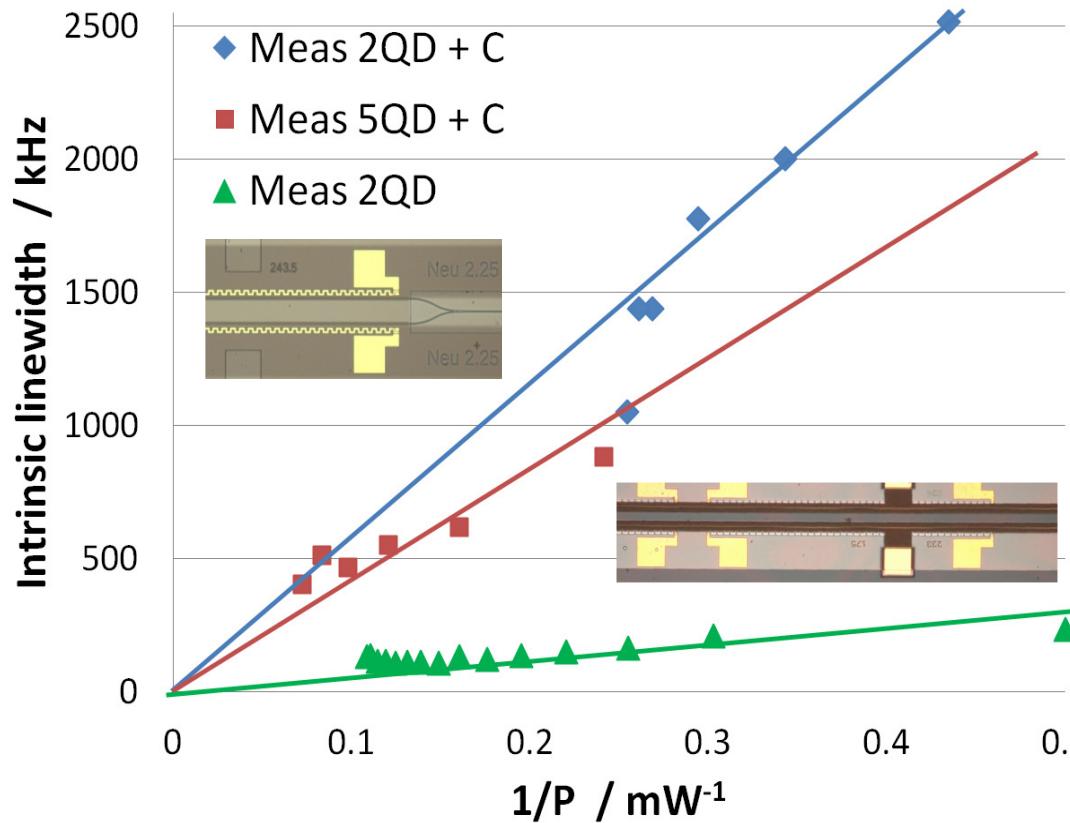
- 2 QD layer design
- QD DFB laser cleaved from monolithic chip show stable SMSR and > 9 mW/facet
- Linewidth of **110 kHz** obtained nearly power independent between 4 – 9 mW/facet



About 1.2 mm long QD DFB laser with two cleaved facets and 1st order lateral gratings



Impact of QD material and laser design/operation



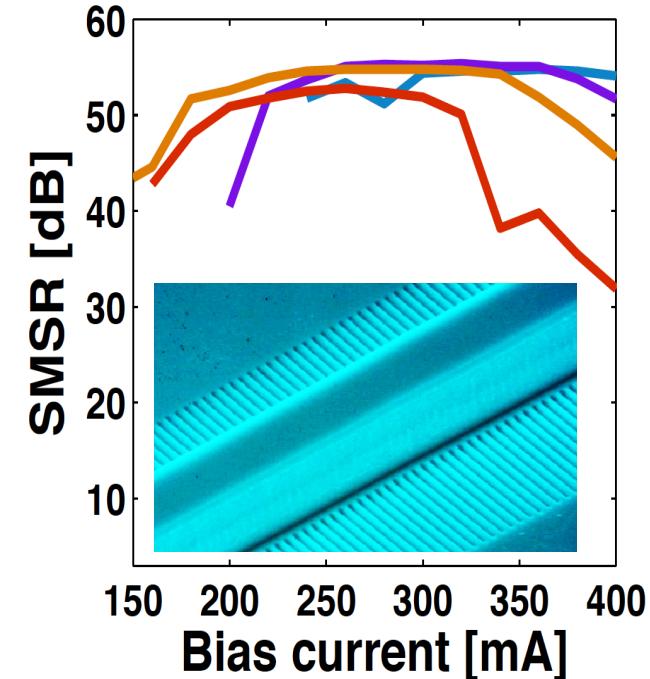
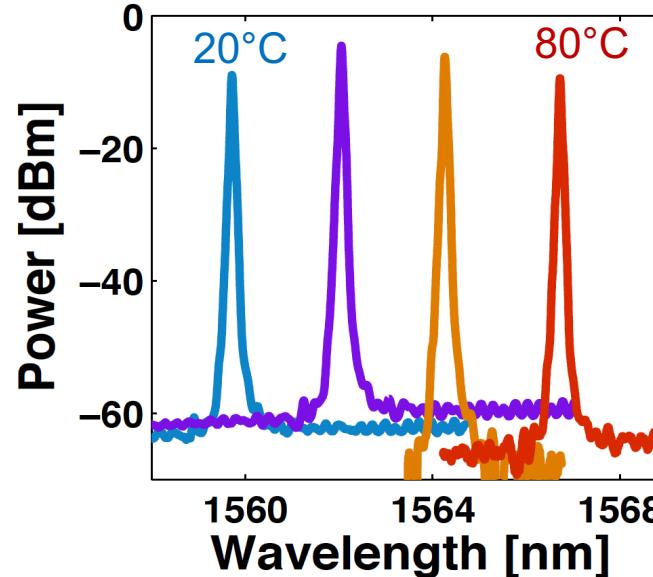
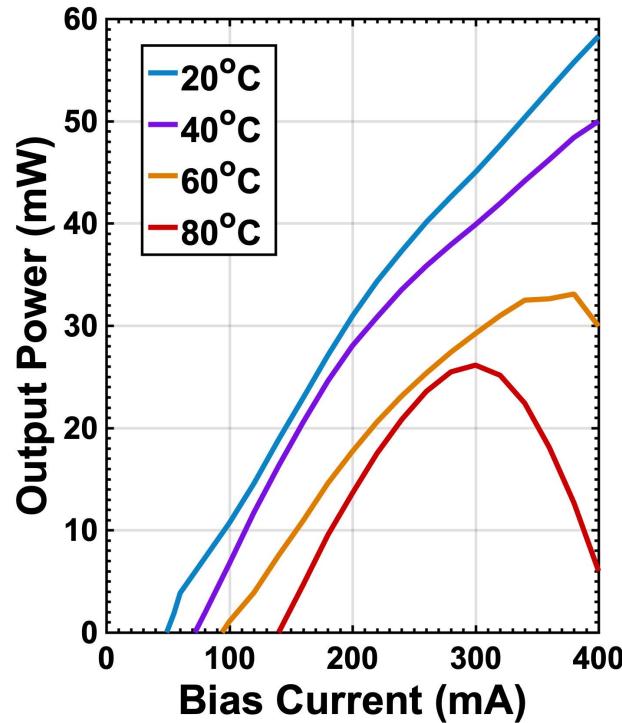
$$\Delta\nu \sim (1+\alpha^2)/P$$

A. Becker et al., Appl. Phys. Lett. 110, 181103 (2017)



- Linewidths of devices of different numbers of QD layers with & without couplers
- Values close to threshold and for very high currents are not considered
- The fitted lines clearly show a linear increase of the linewidth with inverse output power as theoretically expected

QD-DFB-Laser with 5 QD layers



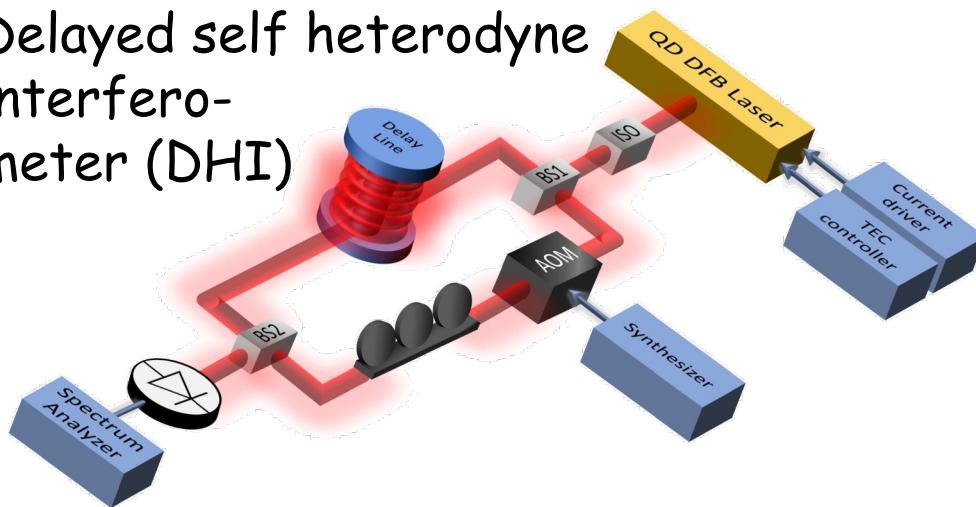
- QD-DFB lasers with 5 QD layers (2 μm ridge, 1.5 mm length, AR/HR coating)
- 1st order DFB gratings (240 nm) with $\lambda/4$ phase shift distributed in 3 steps
- High single mode output power of > 58 mW (@20 °C) and 26 mW (@80 °C)
- High SMSR (> 50 dB) over a wide bias current range and operation temperature

T. Septon et al., PW, Novel In-Plane ..., Monday [10939-5]
T. Septon, A. Becker et al., OFC, San José (March 2019)

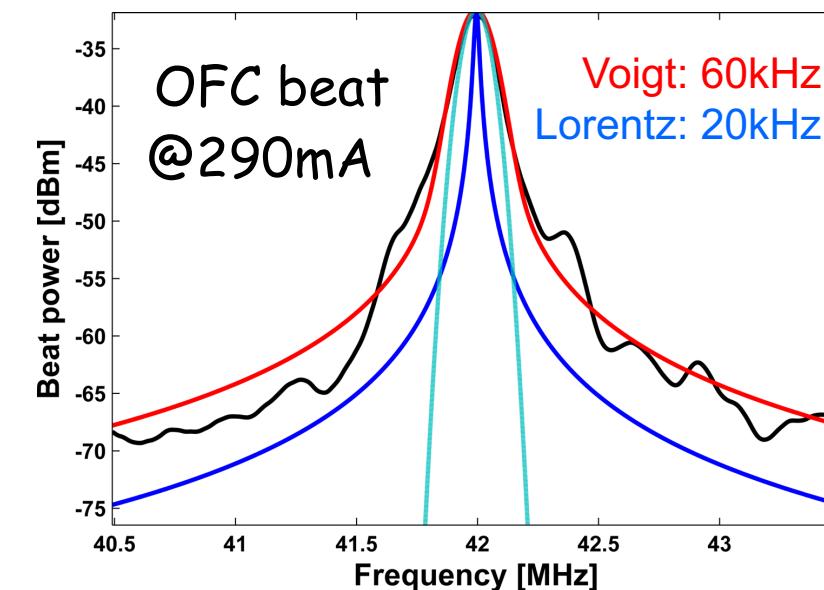
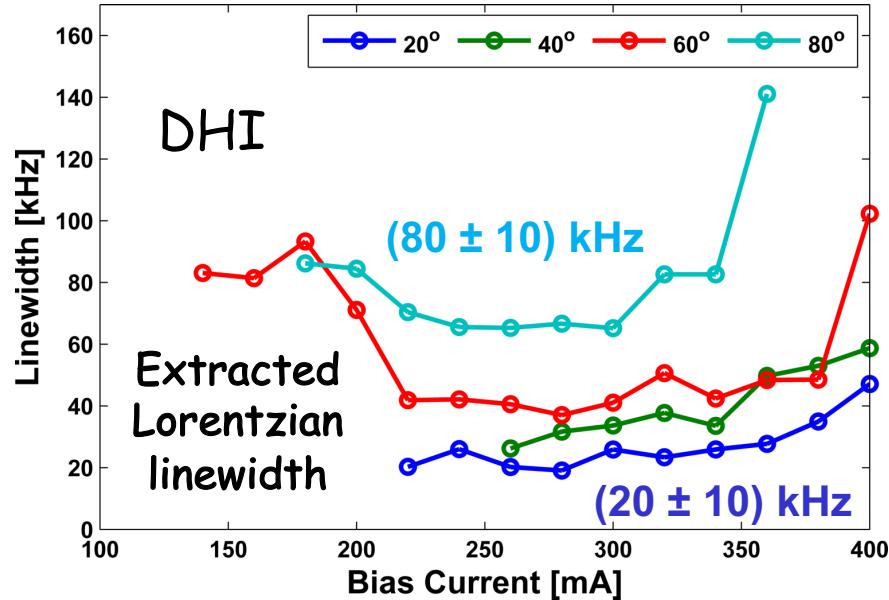
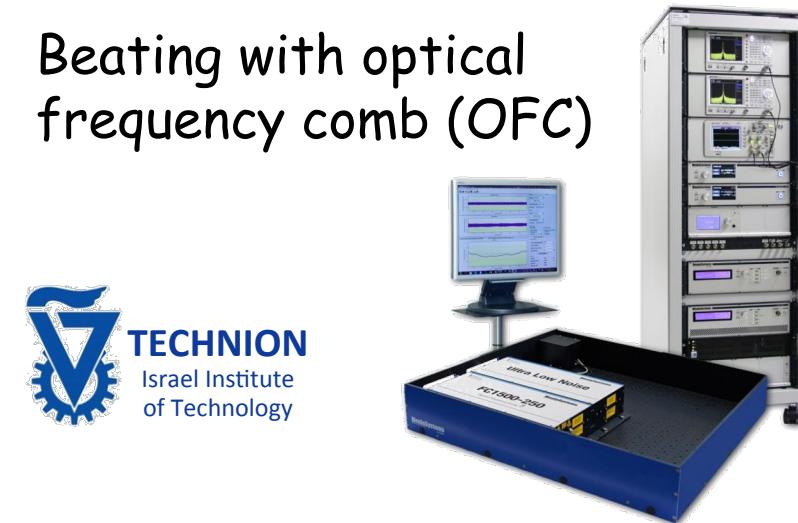


Linewidth Comparison between DHI and OFC beat

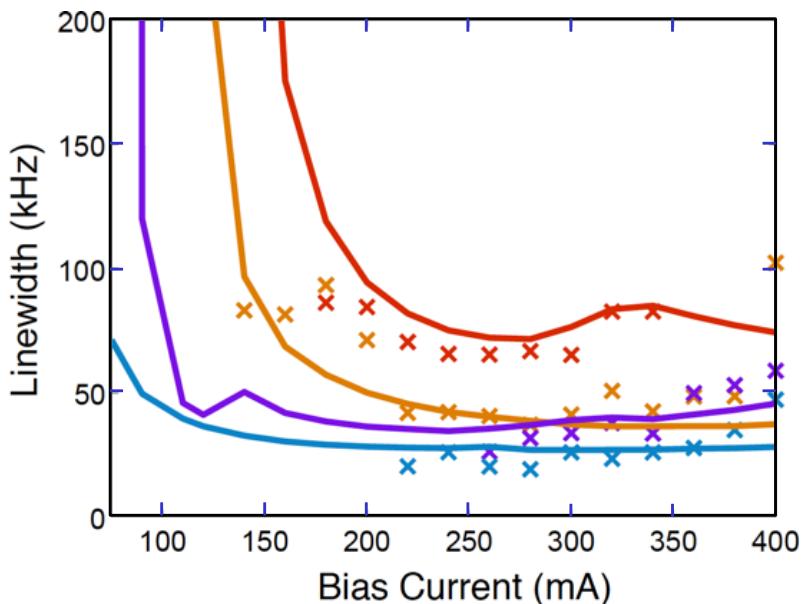
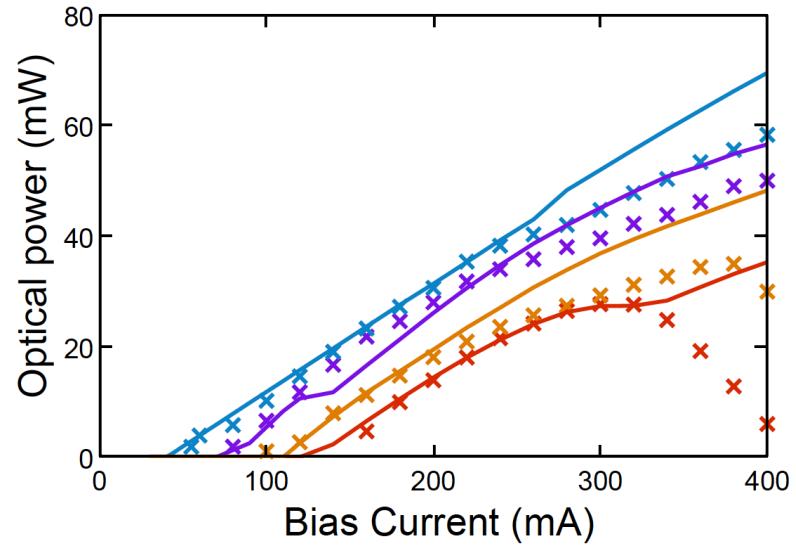
Delayed self heterodyne interferometer (DHI)



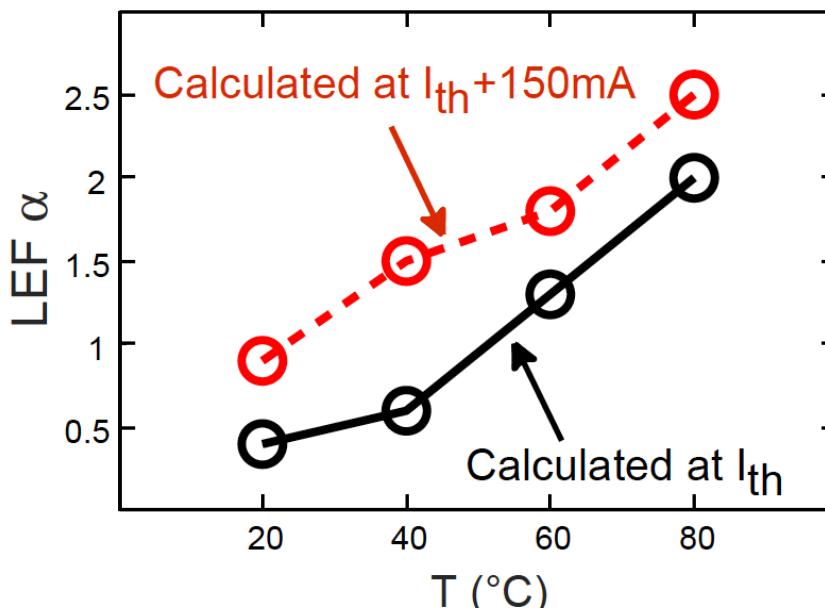
Beating with optical frequency comb (OFC)



Theory & Linewidth Enhancement Factor



- Advanced theory including temperature and current dependent α -factor
- Can be well fitted to P-I curves and linewidths



- T and I dependent α -factor can be extracted with 0.4 at 20 °C

T. Septon et al., Optica 6, 1071 (2019)



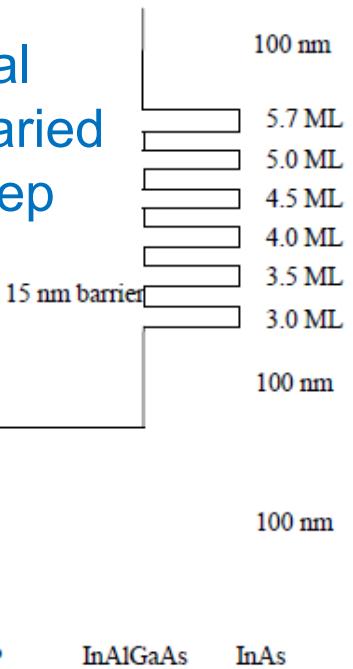
Outlook (Expansion in Wavelength)

- Beyond 1.55 μm (C+L band)
- 1.3 μm (O-band)

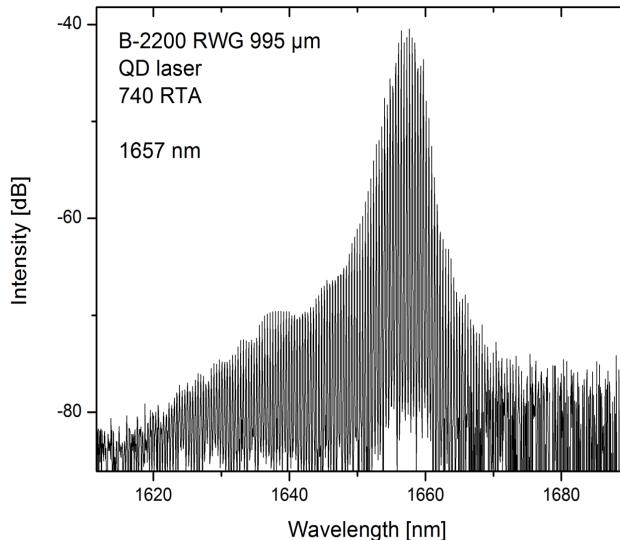
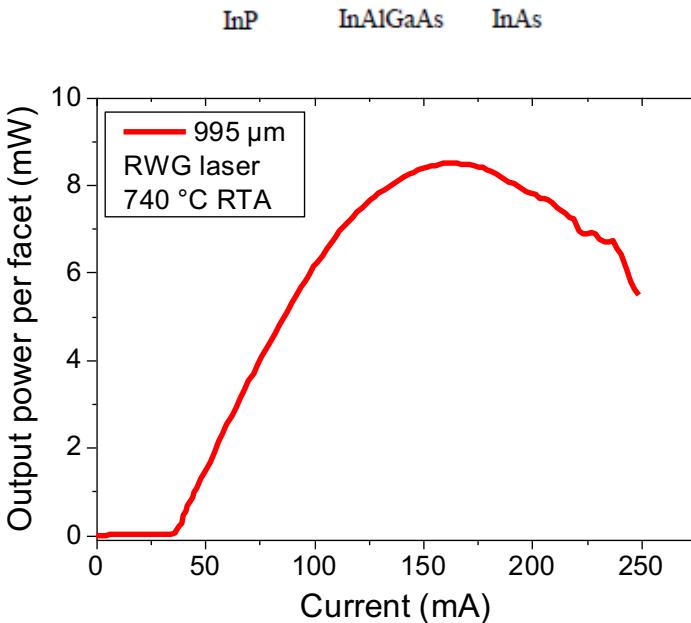
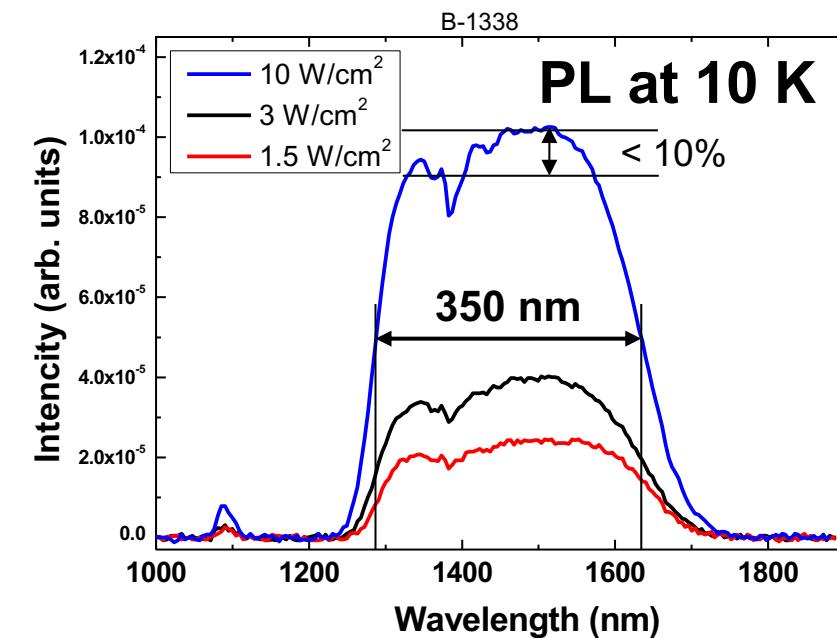


Broadband Light Source (> 300 nm)

QDs nominal thickness varied in 0.5 ML step



Emission range
1250-1700 nm
at 10 K

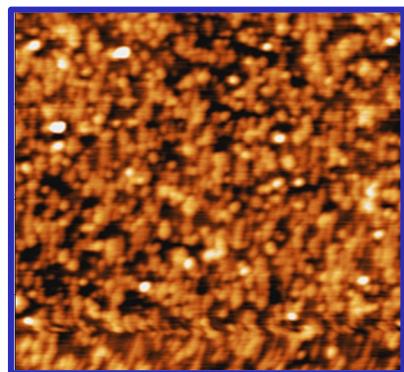


RWG laser emitting at 1.66 μm

-- unpublished --

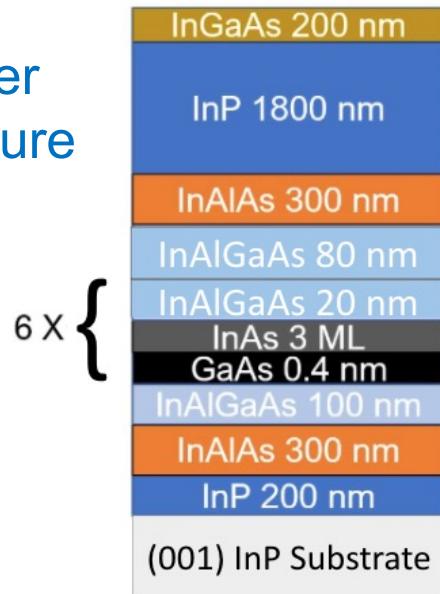


1.3 μm InP-Based QD Lasers

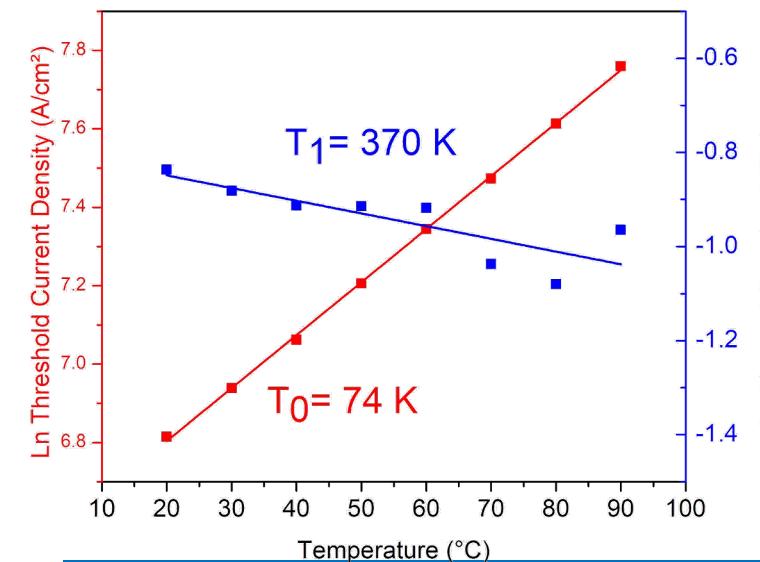
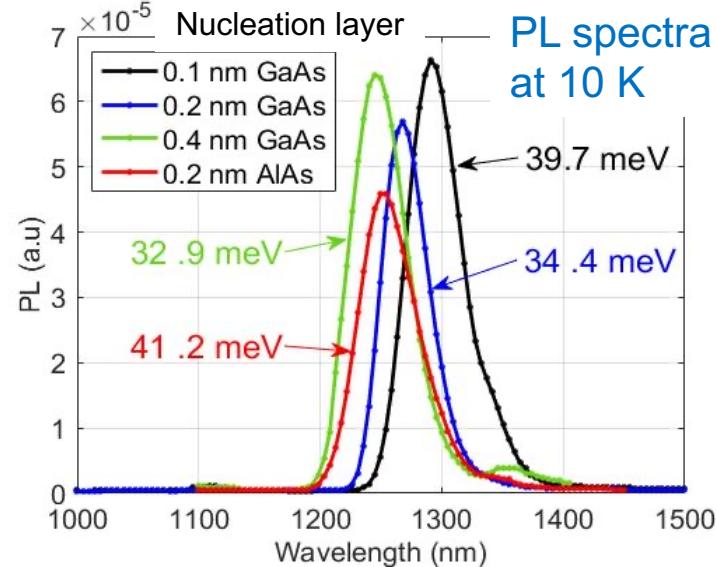
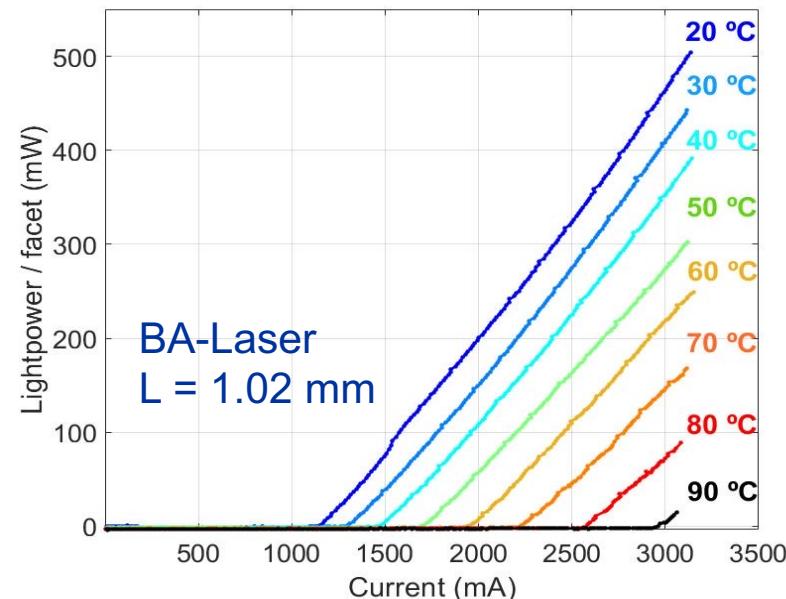
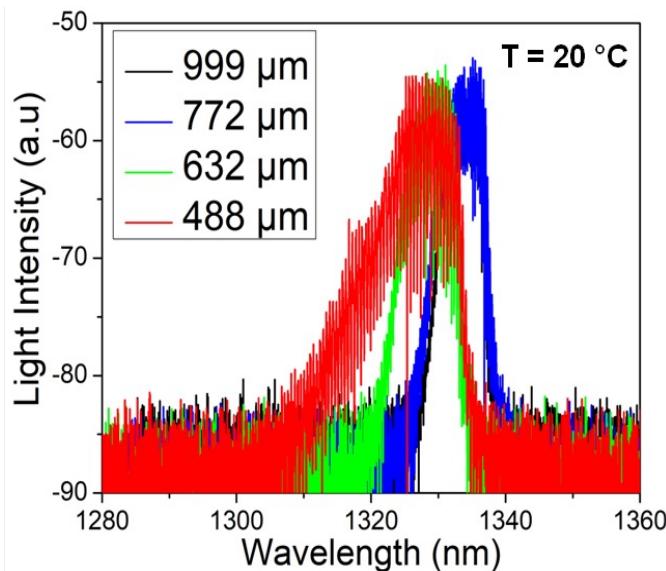


AFM: 2 x 2 μm

Laser structure



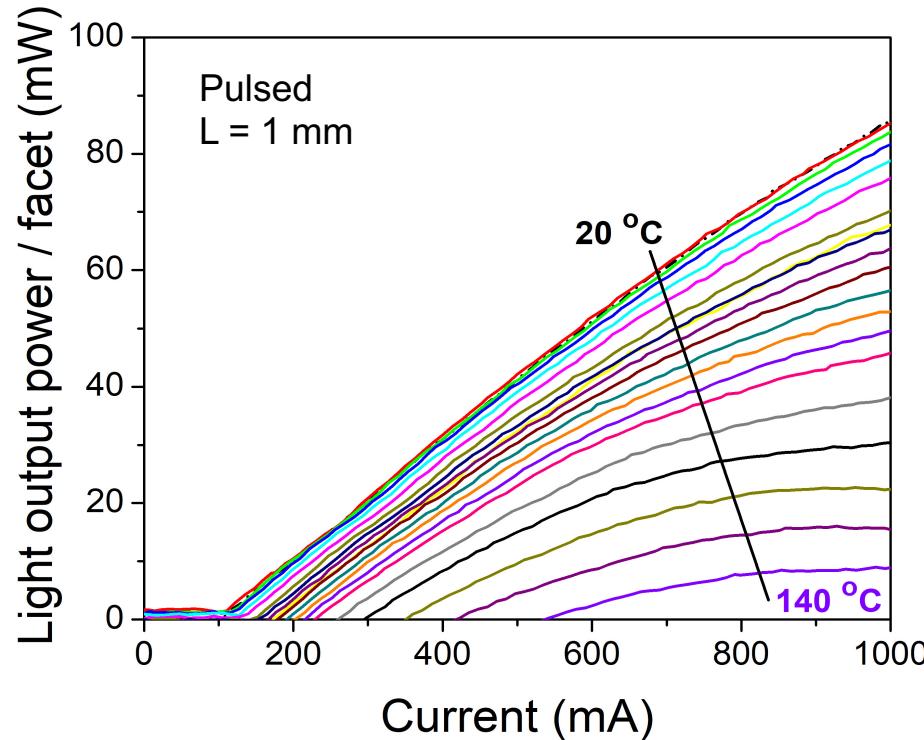
Electroluminescence Spectra



-- sumitted for publication --



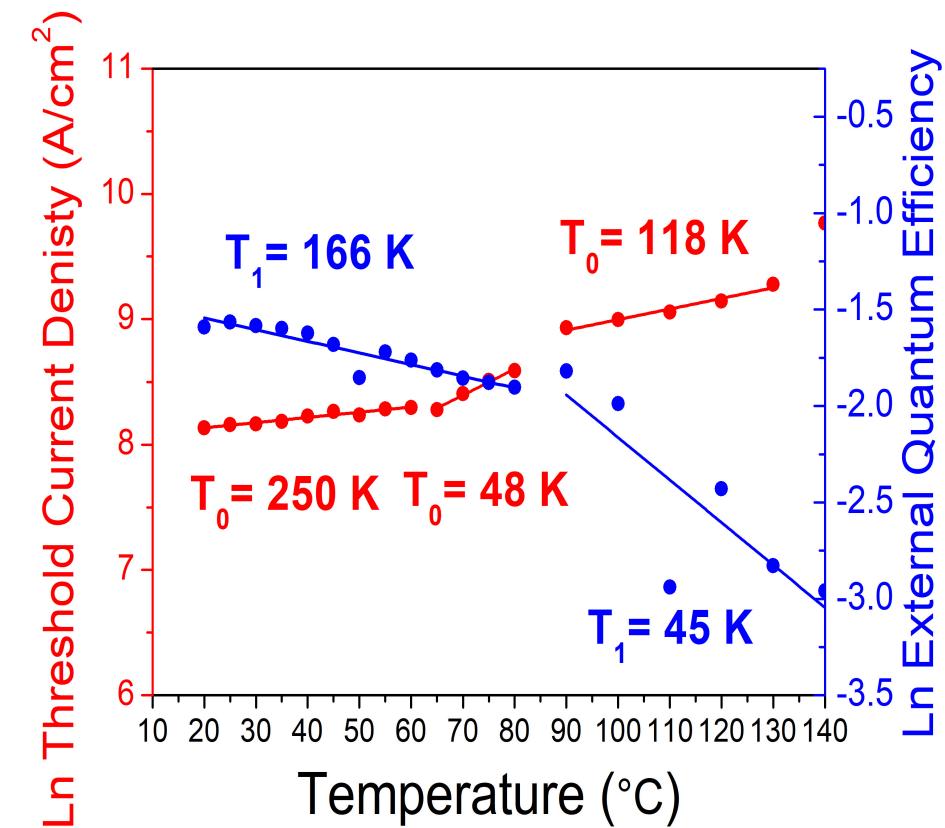
Temperature Characteristics of RWG O-band QD laser



- RWG laser with $L_c = 1 \text{ mm}$ (as-cleaved)

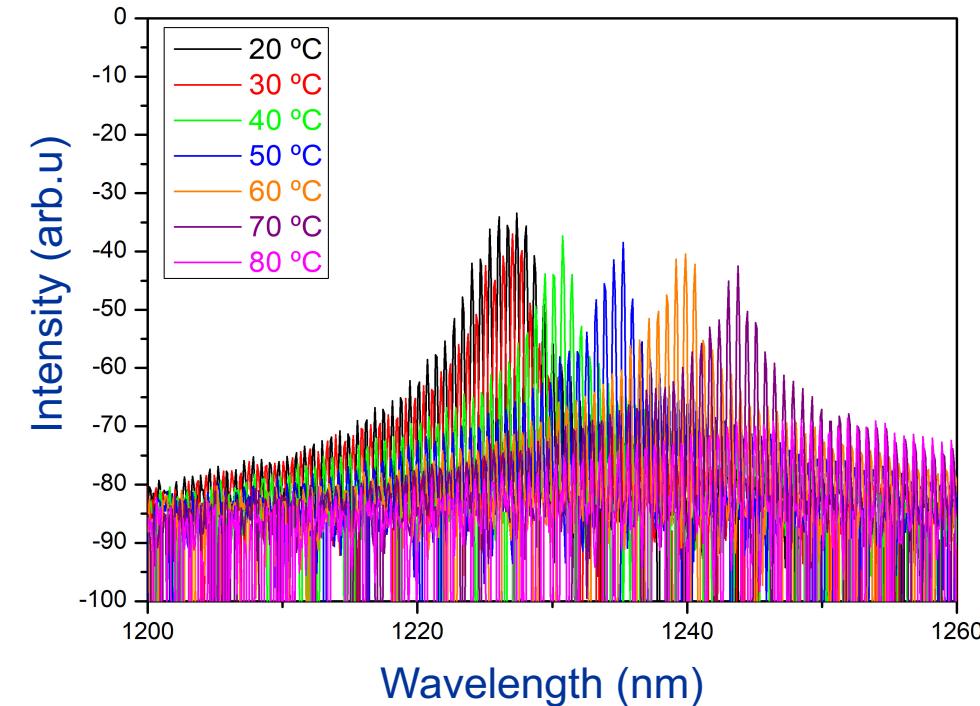
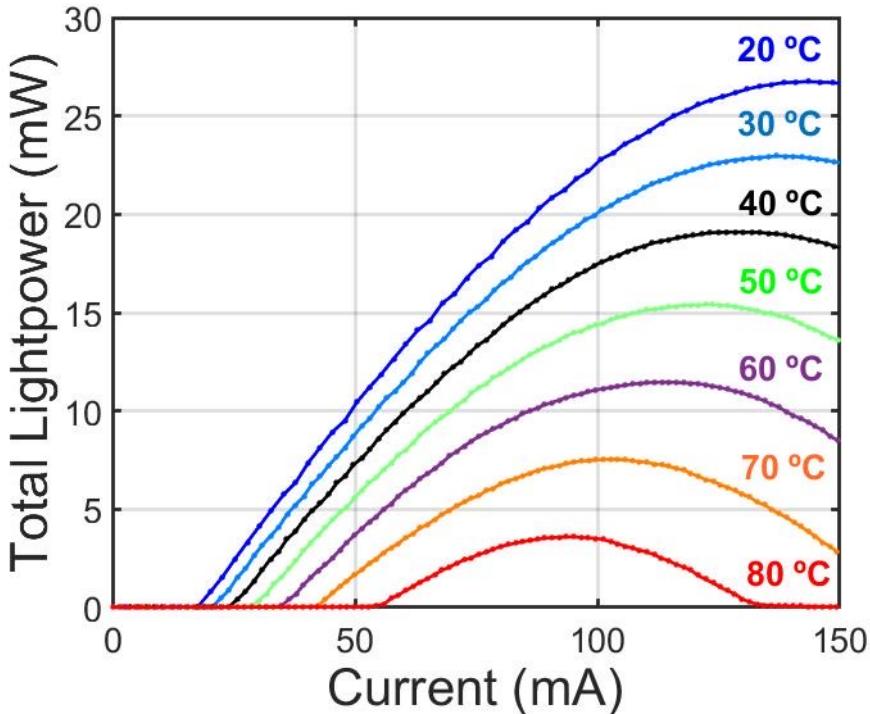
- High T_0 value of 250 K
- T_1 value still very moderate

→ further carrier confinement improvement necessary



CW operation of short cavity RWG laser

Cavity length of 321 μm with back facet HR coated
and front facet as cleaved (ridge width = 2 μm)



- P-I characteristics of short cavity RWG laser
- CW operation up to 80 °C
- 27 mW output power at RT
- Spectra of 321 μm long RWG laser at different operation temperature
- Red shift of wavelength with about 0.3 nm/K



Quantum Dot Lasers

- Record values in temperature stability for $1.5 \mu\text{m}$ lasers
($T_0 = 140 \text{ K}$, $T_1 > 900 \text{ K}$)
- Record values in modulation speed
(26 GBit/s at 80°C , 25 Gbaud PAM4)

Narrow-Linewidth QD-DFB-Lasers

- Clear proof of impact of QD materials on linewidth narrowing
(one order of magnitude improvement in linewidth by $\alpha < 1$)
- Ultra-Narrow Linewidth for optimized layer design
(new record linewidth of $(20 \pm 10) \text{ kHz}$ for QD lasers)

Expansion to shorter and longer wavelengths

- 1.3 and $1.66 \mu\text{m}$ lasers (O to L band)
- Broadband gain ($> 350 \text{ nm}$ bandwidth)



Acknowledgements

EU Projects:



BMBF Project:



PEARLS

Israeli Funding: - Israel Science Foundation
- Israeli Innovation Authority (project Peta Cloud)

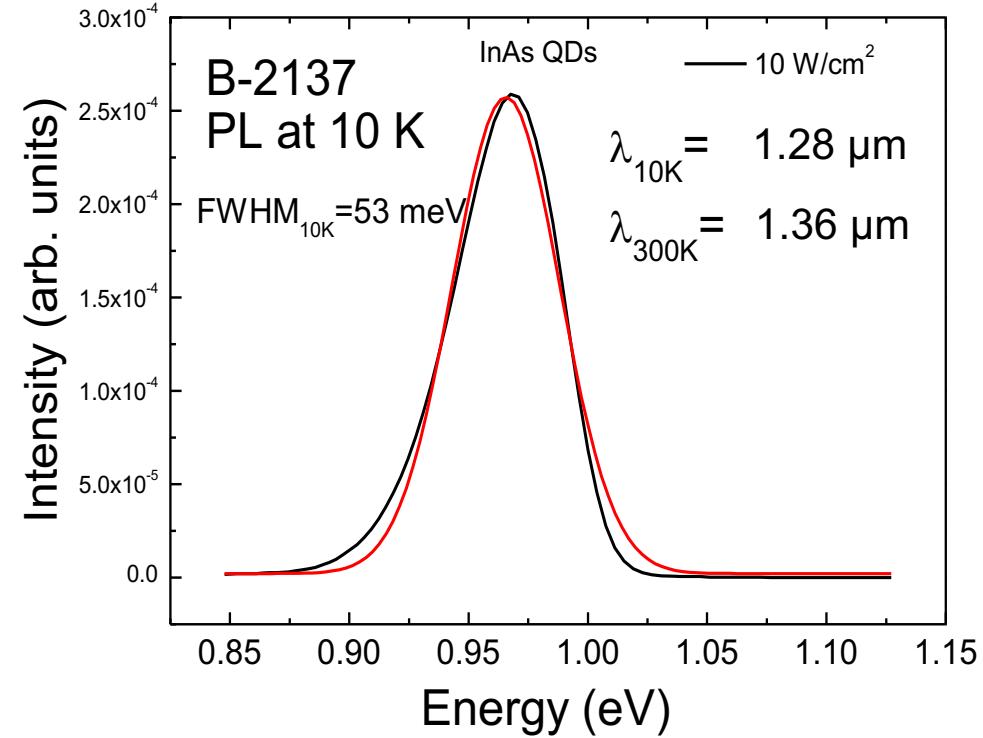
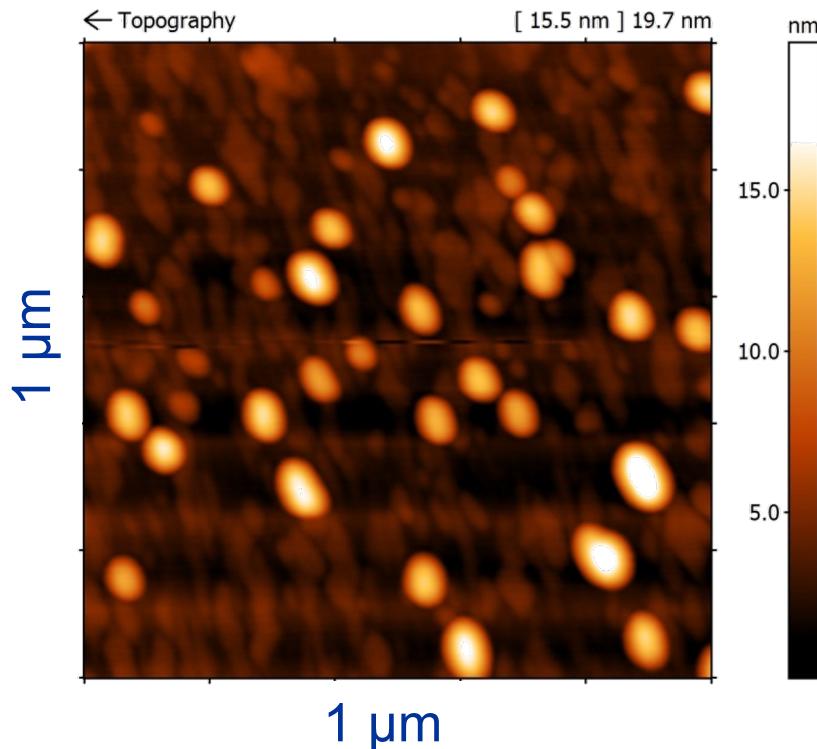
Thank you for your kind attention





First growth of smaller QDs

3.0 ML InAs QDs; $T_s = 480 \text{ }^\circ\text{C}$; V/III ratio = 27

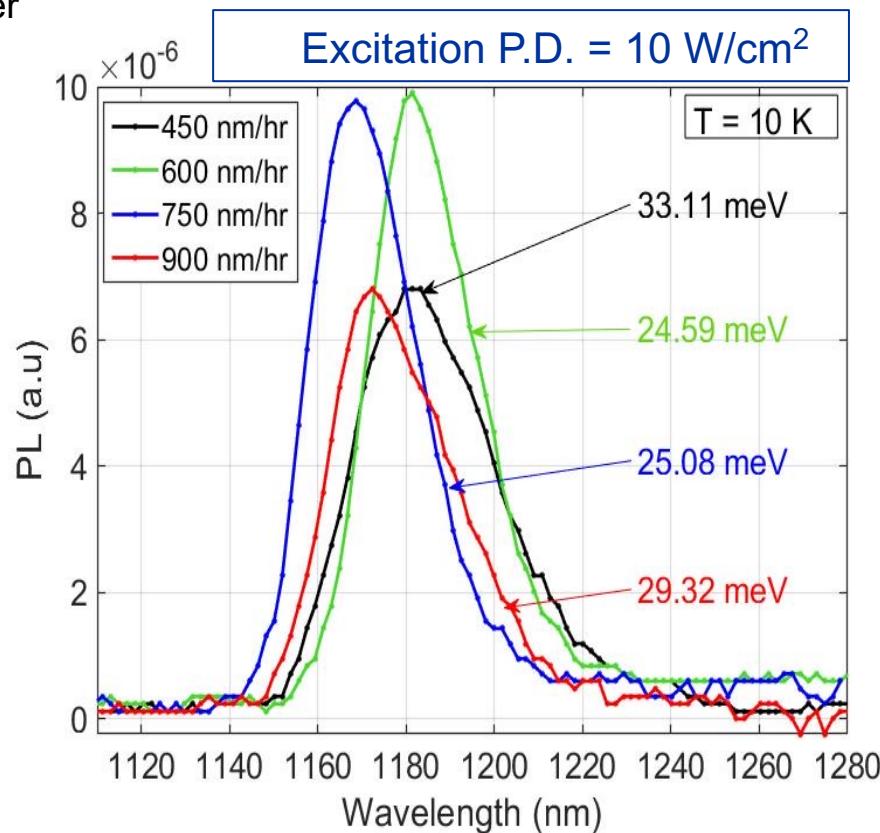
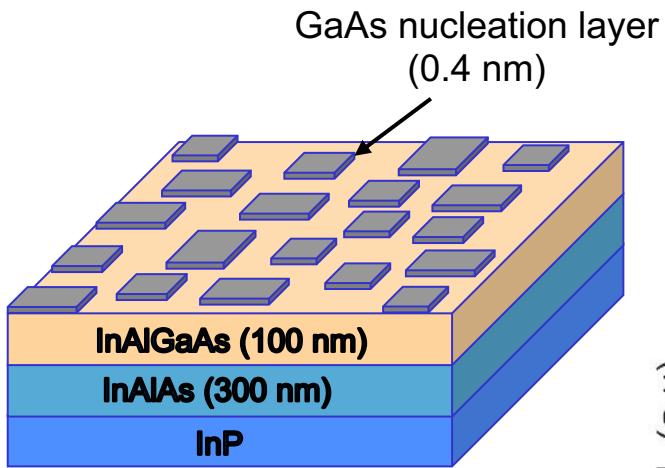


High-density QD growth at 1.3 μm not possible by only adapting standard growth parameters

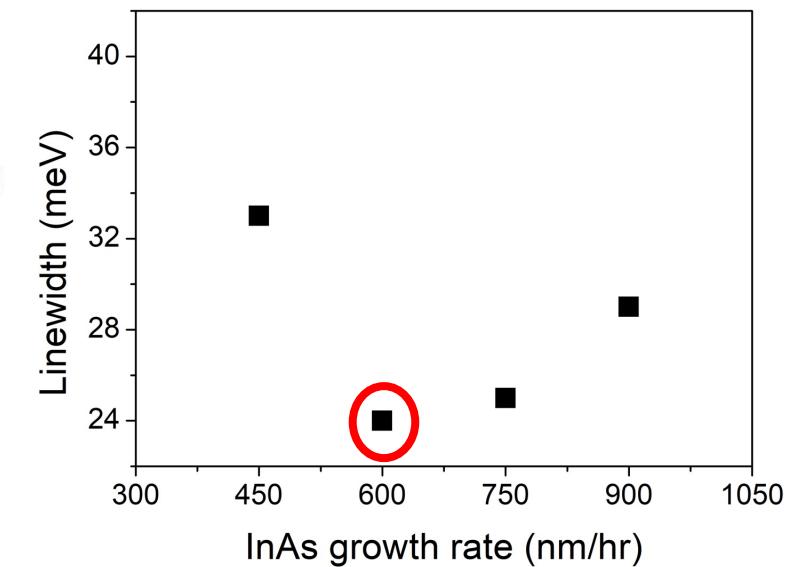
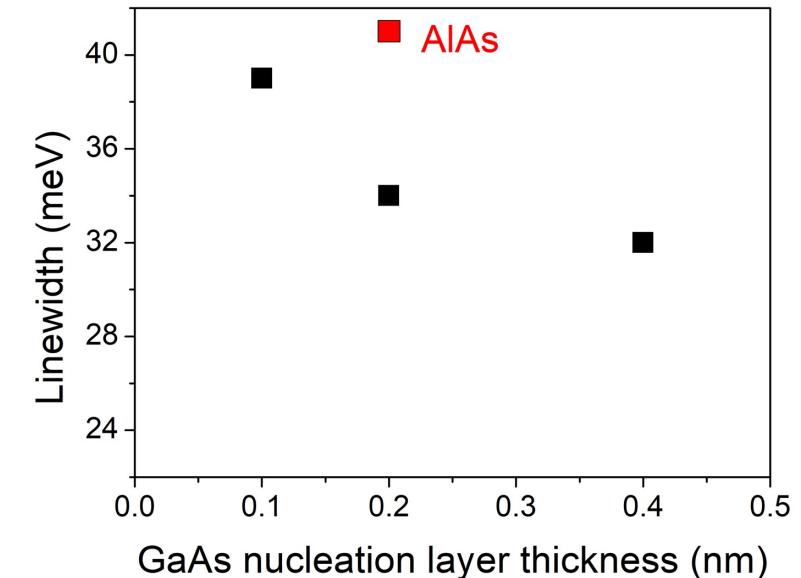
- Nominal thickness of QD layer
- V/III ratio
- Growth temperature

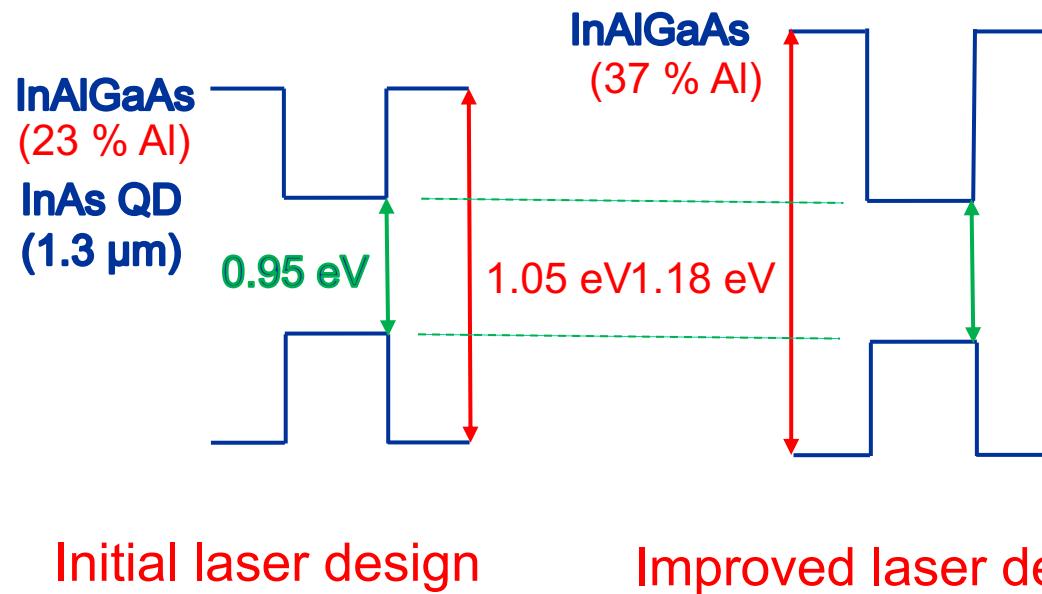
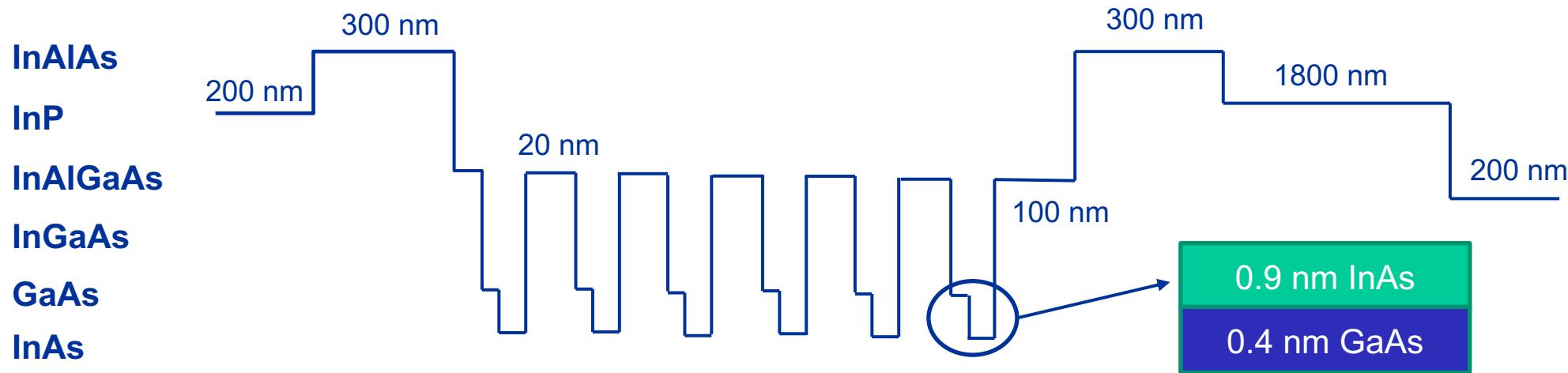


Introduction of additional strained nucleation layer



- Variation of nucleation layer thickness and growth rate
- Reduction from 53 meV (low QD density) to 24 meV (high QD density)
- $< 1.3 \mu\text{m}$ emission possible with increasing nucleation sites



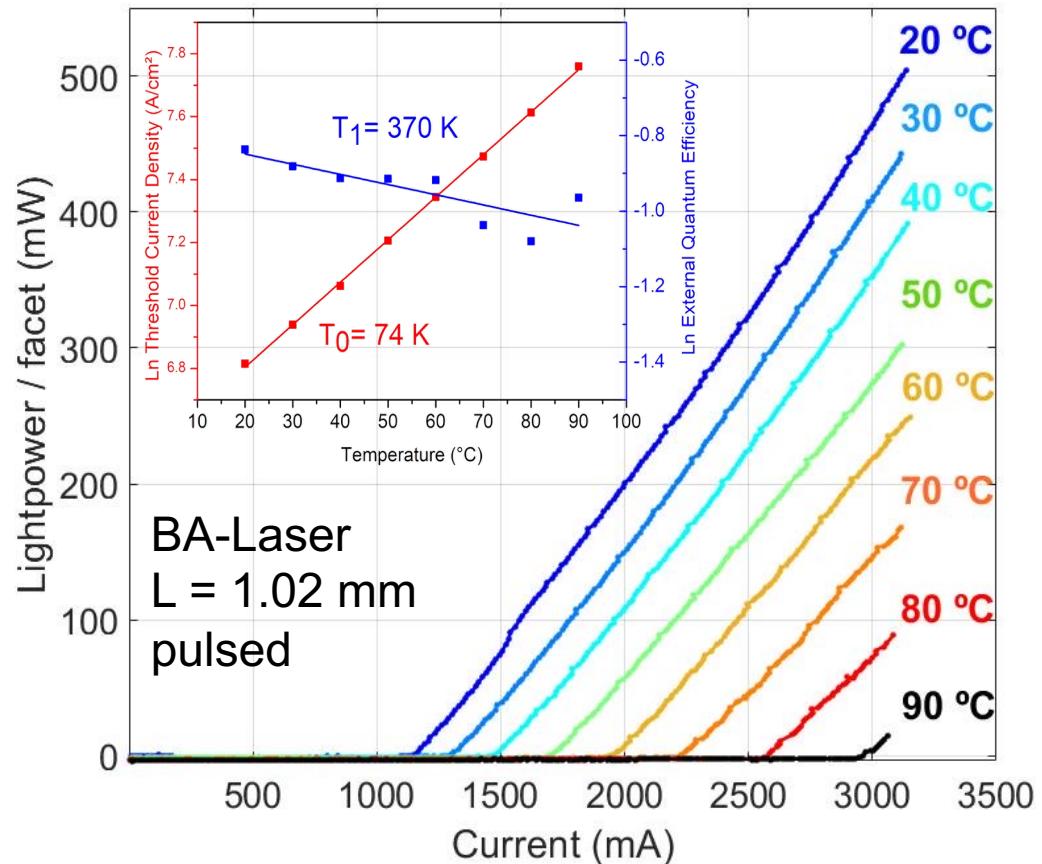


- Initial design used same barriers than 1.55 μm QD lasers.
(\rightarrow limited carrier confinement)
- Improved design with increased barrier height to obtain similar confinement for 1.3 μm QDs than for 1.55 μm QDs.



BA Laser evaluation

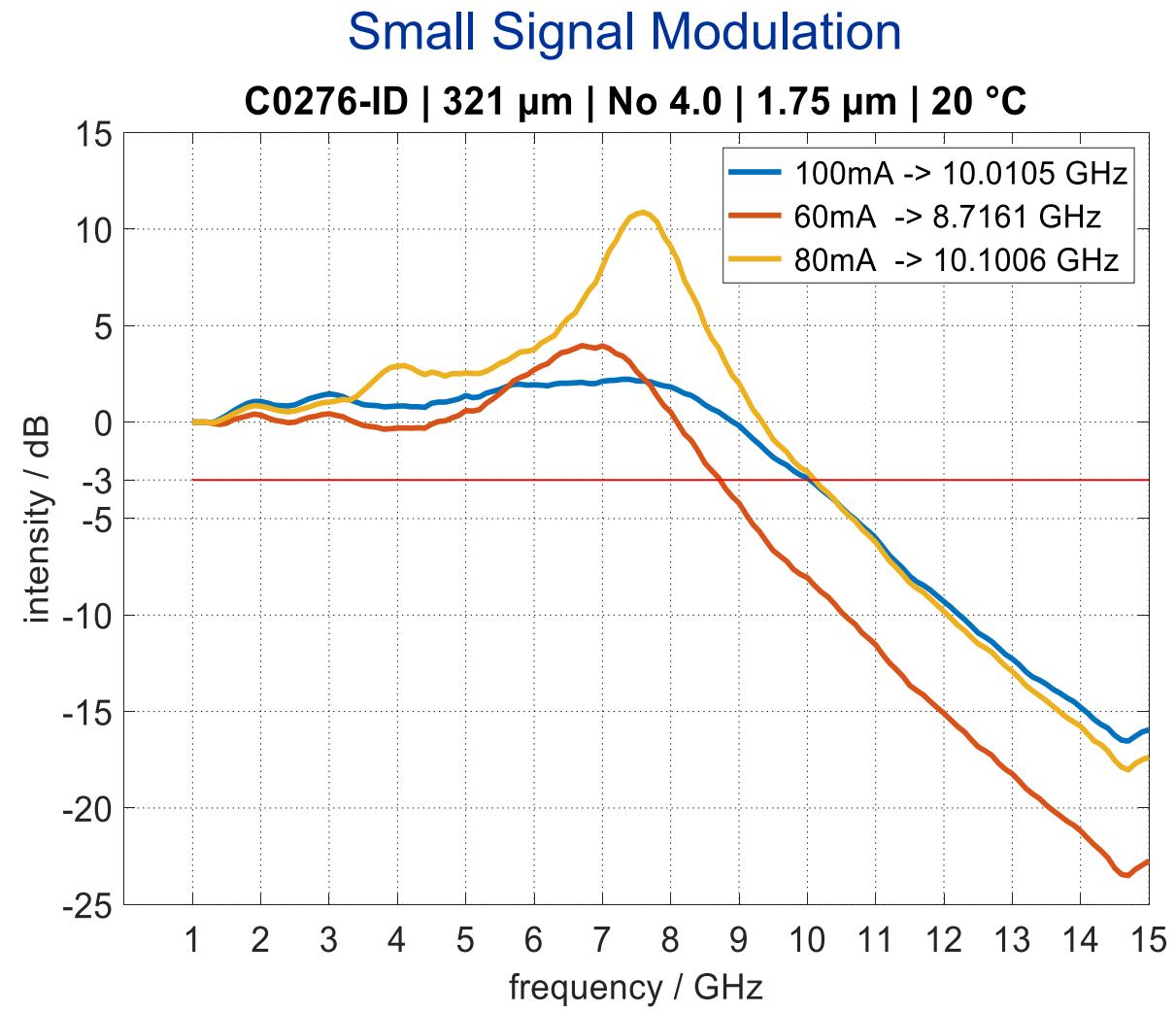
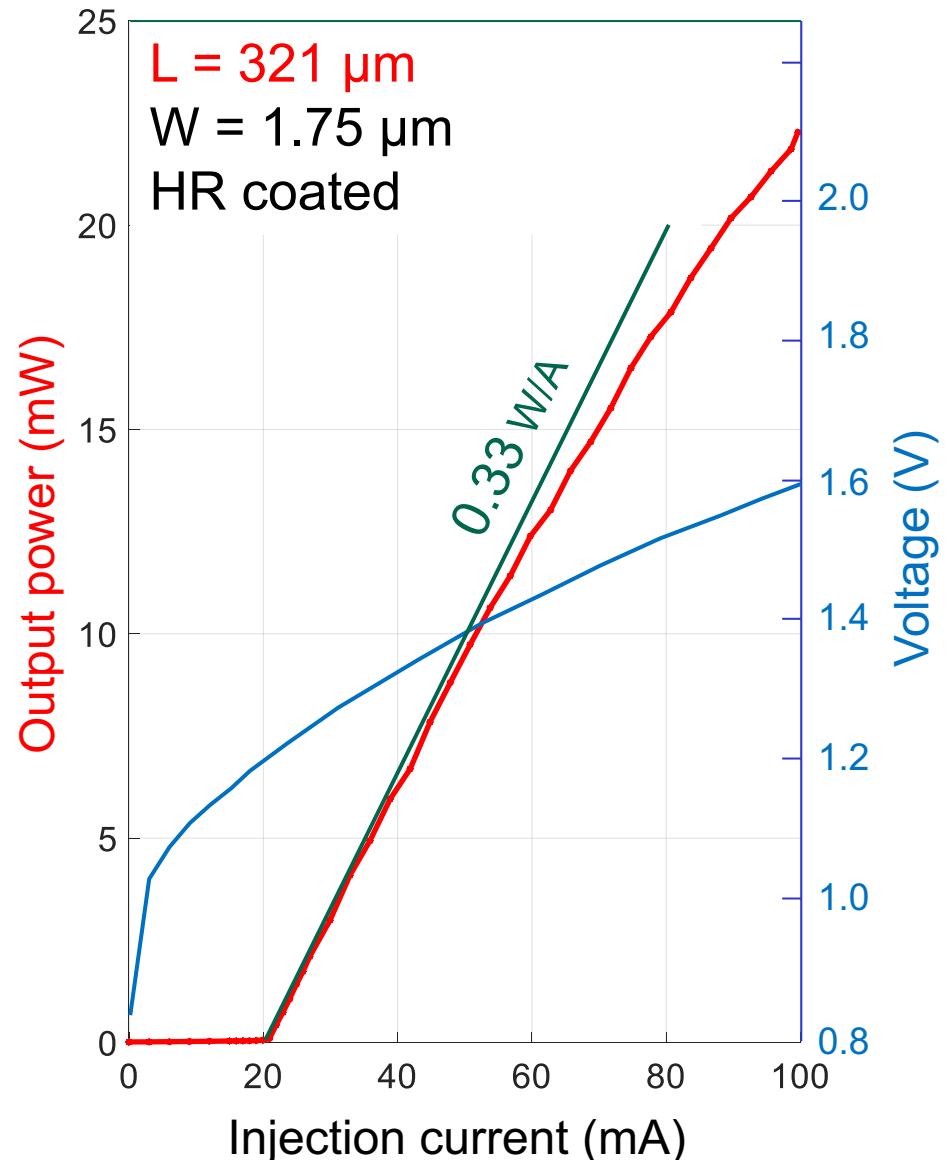
Parameter	Initial	Improved
λ (μm)	1.36	1.22
J_{th} (kA/cm^2)	0.72	0.67
η_i	0.68	0.82
α_i (cm^{-1})	8.8	11.3
J_0 (kA/cm^2)	0.46	0.47
Γg_0 (cm^{-1})	78	91
Γg_0 (cm^{-1}) per QD layer	13	15



- 100 μm broad area laser (cleaved facets, variable cavity lengths)
- Improved internal quantum efficiency due to better carrier confinement
- High modal gain up to 15 cm^{-1} per QD layer similar to 1.55 μm QD lasers



SSM response of short cavity RWG laser



- SSM bandwidth of 10 GHz (at 20 °C)

